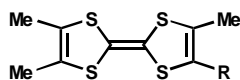


R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
COOH	190-192	CH ₃ CN ^{d)}				5
COOCH ₃	132-134	CH ₃ CN ^{c)}				6
C ₁₇ H ₃₅		hexane-CHCl ₃ ^{b)}				1
C(S)NHCH ₃	171-172	CHCl ₃	0.41	0.79	CH ₃ CN 0.1M TBAP	2
(CH ₂) ₈ COOCH ₃						3
(CH ₂) ₈ COOH						3
C ₆ H ₄ OC(O)CH ₃ ^p	130	CHCl ₃				4
C ₆ H ₄ OH ^p	192	CHCl ₃				4
(CH ₂) ₈ CONH(CH ₂) ₁₀ COOH						3
(CH ₂) ₈ [CONH(CH ₂) ₁₀] ₂ COOH						3

^{a)}Solvent for ¹HNMR. ^{b)}Solvent for preparation of LB film. ^{c)}Solvent for recrystallization. ^{d)}Solvent for UV.

- (1) S. V. Ayrape, Tians, T. S. Berzina, S. A. Shikin, and V. I. Troisky, *Thin. Solid. Films.*, **210**, 261 (1992).
- (2) A. J. Moore, M. R. Bryce, A. S. Batsanov, J. N. Heaton, C. W. Lehmann, J. A. K. Howard, N. Robertson, A. E. Underhill, and I. F. Perepichka, *J. Mater. Chem.*, **8**, 1541 (1998).
- (3) K. Lerstrup, M. Jørgensen, and S. Rosenkilde, *Synth. Met.*, **42**, 1475 (1991).
- (4) J. M. Fabre, D. Serhani, K. Saoud, and A. K. Gouasmia, *Bull. Soc. Chim. Belg.*, **102**, 615 (1993).
- (5) Ya. N. Kreitsberga, and O. Ya. Neiland, *J. Org. Chem. USSR.*, **22**, 2131 (1986).
- (6) Ya. N. Kreitsberga, R. B. Kampare, and O. Ya. Neiland, *Chem. Heterocycl. Comp.*, 358 (1982).

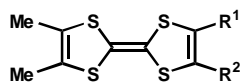


R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
H						4
C ₁₈ H ₃₇	67-68					1
CH ₂ OH	204	acetone	0.29	0.68	CH ₃ CN 0.1M TBAP ^{c)}	1
CHO	217-218	CH ₂ Cl ₂ ^{b)}	0.46	0.86	CH ₃ CN 0.1M TBAP ^{c)}	1
COOH	170-180	toluene ^{b)}	0.43	0.73	CH ₃ CN 0.1M TBAP ^{c)}	1
COOCH ₃	142					8
COOCH ₂ C ₆ H ₅	165					9
CH ₂ OCH ₃	145-146	acetone			0.1M TBAP ^{c)}	1
C(S)NHCH ₃	174-175	toluene ^{b)}	0.38	0.76	CH ₃ CN 0.1M TBAP ^{c)}	2
CH ₂ OC(O)CH ₃	136-137	acetone	0.35	0.74	CH ₃ CN 0.1M TBAP ^{c)}	1
CH=CHCHO	178-179	acetone	0.44	0.8	CH ₃ CN 0.1M TBAP ^{c)}	1
CH=CHC(O)OEt	128-129	acetone	0.4	0.77	CH ₃ CN 0.1M TBAP ^{c)}	1
C(O)Ph	127-128	CH ₃ CN ^{b)}	0.44	0.82	CH ₃ CN 0.1M TBAP ^{c)}	1
CH(OH)Ph	105-106	acetone	0.31	0.7	CH ₃ CN 0.1M TBAP ^{c)}	1
C(O)NHPPh	190-191	CH ₃ CN ^{b)}	0.39	0.77	CH ₃ CN 0.1M TBAP ^{c)}	1
C(S)NHPPh	173-175	CH ₃ CN ^{b)}	0.38	0.77	CH ₃ CN 0.1M TBAP ^{c)}	1
C(O)OEt	97-98	acetone	0.4	0.81	CH ₃ CN 0.1M TBAP ^{c)}	1

C(O)C ₁₆ H ₃₃	84-85	acetone ^{b)}	0.4	0.8	CH ₃ CN	0.1M TBAP ^{c)}	1
C ₆ H ₄ OC(O)CH ₃ ^p	232	CHCl ₃					6
C ₆ H ₄ OH ^p	165	CHCl ₃					6
SC(O)Ph	163-164	acetone	0.39	0.73	CH ₃ CN	0.1M TBAP ^{c)}	1
COCl	193-194	acetone	0.37	0.73	CH ₃ CN	0.1M TBAP ^{c)}	1
SCH ₃	119	hexane ^{b)}	0.28	0.73	CH ₂ Cl ₂	0.1M TBAHP	3
SC ₁₈ H ₃₇	68	hexane ^{b)}	0.27	0.78	CH ₂ Cl ₂	0.1M TBAHP	3
SCH ₂ C ₆ H ₅	127	hexane ^{b)}	0.27	0.81	CH ₂ Cl ₂	0.1M TBAHP	3
S(CH ₂) ₁₀ COOC ₂ H ₅	59	hexane ^{b)}	0.77	0.77	CH ₂ Cl ₂	0.1M TBAHP	3
S(CH ₂) ₁₅ COOC ₂ H ₅	71	hexane ^{b)}	0.27	0.78	CH ₂ Cl ₂	0.1M TBAHP	3
S(CH ₂) ₁₀ COOCH ₃							5
S(CH ₂) ₁₅ COOCH ₃							5
S(CH ₂) ₁₀ COOH							5
S(CH ₂) ₁₅ COOH							5
S(CH ₂) ₁₀ CONH(CH ₂) ₁₀ COOH							5
S(CH ₂) ₁₅ CONH(CH ₂) ₁₀ COOH							5
PPh ₂	158-160	CH ₃ CN ^{b)}	0.23	0.74	CH ₂ Cl ₂	0.1M TBAHP ^{d)}	7

^aSolvent for ¹HNMR. ^bSolvent for recrystallization. ^cV vs. Ag / AgCl. ^dV vs. Fc⁺ / Fc.

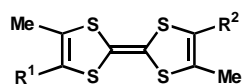
- (1) A. J. Moore, M. R. Bryce, A. S. Batsanov, J. C. Cole, and J. A. K. Howard, *Synthesis*, 675 (1995).
- (2) A. J. Moore, M. R. Bryce, A. S. Batsanov, J. N. Heaton, C. W. Lehmann, J. A. K. Howard, N. Robertson, A. E. Underhill, and I. F. Perepichka, *J. Mater. Chem.*, **8**, 1541 (1998).
- (3) M. Jørgensen, K. A. Lerstrup, and K. Bechgaard, *J. Org. Chem.*, **56**, 5684 (1991).
- (4) K. Lerstrup, I. Johannsen, M. Jørgensen, *Synth. Met.*, **27**, B9. (1988).
- (5) K. Lerstrup, M. Jørgensen, and S. Rosenkilde, *Synth. Met.*, **42**, 1475 (1991).
- (6) J. M. Fabre, D. Serhani, K. Saoud, and A. K. Gouasmia, *Bull. Soc. Chim. Belg.*, **102**, 615 (1993).
- (7) M. Fourmigue, S. Jarshow, and P. Batail, *Phosphorus, Sulfur, and Silicon*, **175**, 175 (1993).
- (8) H. Mora, J. M. Fabre, L. Giral, and C. Montginoul, *Bull. Soc. Chim. Belg.*, **101**, 741 (1992).
- (9) H. Mora, J. M. Fabre, L. Giral, C. Montginoul, R. Sagnes, and F. Schue, *Makromol. Chem.*, **193**, 1337 (1992).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. Ag / AgCl)	reference	
S(CH ₂) ₂ CN	SCH ₃	145-147	MeOH ^{b)}				2	
S(CH ₂) ₂ CN	SCH ₃	86-87	hexane ^{b)}				2	
COOCH ₃	SCH ₃	145	MeOH ^{b)}	0.50	0.86	CH ₃ CN	TBAHP	4
C ₆ H ₄ CH ₃ ^p	SC ₁₈ H ₃₇	65-70	CH ₃ CN	0.47	0.82	CH ₃ CN	0.1M TBAP	1
C ₁₆ H ₃₃	C ₁₇ H ₃₅		CH ₃ CN ^{c)}					3

^aSolvent for CV. ^bsolvent for recrystallization. ^cSolvent for UV.

- (1) M. R. Bryce, A. J. Moore, D. Lorcy, A. S. Dhindsa, and A. Robert, *J. Chem. Soc., Chem. Commun.*, 470 (1990).
- (2) L. Binet, J. M. Fabre, *Synthesis*, 1179 (1997)
- (3) Ya. N. Kreitsberga, D. V. Bite, V. E. Kampar, R. B. Kampare, and O. Ya. Neiland, *J. Org. Chem. USSR.*, **17**, 1055 (1980).
- (4) I. V. Sudmale, G. V. Tormos, V. Yu. Khodorkovsky, A. S. Edzina, O. J. Neilands, and M. P. Cava, *J. Org. Chem.*, **58**, 1355 (1993).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference	
SCH ₃	SCH ₃		CH ₃ CN	0.455	0.760	CH ₃ CN	1	
H	COOH	184					2	
H	COOCH ₃	88-94					2	
H	COOC ₂ H ₅	62-64	hexane ^{b)}	0.43	0.790	CH ₃ CN	0.1M TEAP	3
H	COOCH ₂ C ₆ H ₅	127					4	

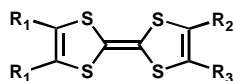
^{a)}Solvent for CV. ^{b)}Solvent for recrystallization.



(1) M. Jørgensen, K. Bechgaard, T. Bjørnholm, P. Sommer-Larsen, L. G. Hansen, and K. Schaumburg, *J. Org. Chem.*, **59**, 5877 (1994).

(2) H. Mora, J. M. Fabre, L. Giral, and C. Montginoul, *Bull. Soc. Chim. Belg.*, **101**, 741 (1992).

(3) D. C. Green, *J. Org. Chem.*, **44**, 1476 (1979).

(4) H. Mora, J. M. Fabre, L. Giral, C. Montginoul, R. Sagnes, and F. Schue, *Makromol. Chem.*, **193**, 1337 (1992).



R ₁	R ₂	R ₃	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference	
CO ₂ CH ₃	H	CH ₃	82-85					4	
CO ₂ C ₂ H ₅	H	CH ₃	33-34	hexane ^{c)}	0.54	0.87	CH ₃ CN	0.1M TEAP	5
	H	CH ₃						1	
-(CH ₂) ₃ -	CH ₃	C ₂ H ₅	132	CHCl ₃	0.16	0.52	CH ₃ CN	NaClO ₄	2
	H	CO ₂ CH ₃	141	CH ₂ Cl ₂ ^{b)}				3	

^{a)}Solvent for ¹HNMR. ^{b)}Solvent for chromatography. ^{c)}Solvent for recrystallization.

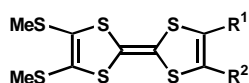
(1) F. Darviche, M.T. Babonneau, H.J. Cristau, E. Torreilles, and J. M. Fabre, *Synth. Met.*, **102**, 1662 (1999).

(2) J. M. Fabre, E. Torreilles, J. P. Gibert, M. Chanaa, and L. Giral, *Tetrahedron Lett.*, 4033 (1977).


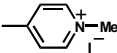
(3) G. C. Papavassiliou, D. J. Lagouvardos, and V. C. Kakoussis, *Z. Naturforsch B*, **46**, 1730 (1991).

(4) H. Mora, J. M. Fabre, L. Giral, and C. Montginoul, *Bull. Soc. Chim. Belg.*, **101**, 741 (1992).

(5) D. C. Green, *J. Org. Chem.*, **44**, 1476 (1979).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference	
H	COOCH ₃		CH ₃ CN ^{b)}				1	
H	CH ₃	72-73	CHCl ₃	0.39	0.71	CH ₃ CN	0.1M TBAP	2
H	C(S)NHCH ₃	134-135	CH ₃ CN	0.52	0.83	CH ₃ CN	0.1M TBAP ^{d)}	3

H	Cl		4
H	Br		4
H	I		4
H		CH ₂ Cl ₂ ^{c)}	5
H		CH ₂ Cl ₂ ^{c)}	5

^aSolvent for ¹HNMR. ^bSolvent for UV. ^cSolvent for preparation of LB film. ^dV vs. Ag / AgCl.

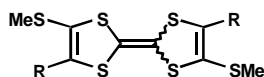
(1) G. C. Papavassiliou, J. S. Zambounis, G. A. Mousdis, V. Gionis, and S. Y. Yiannopoulos, *Mol. Cryst. Liq. Cryst.*, **156**, 269 (1988).

(2) M. Fourmigué, F. C. Krebs, and J. Larsen, *Synthesis*, 509 (1993).

(3) A. J. Moore, M. R. Bryce, A. S. Batsanov, J. N. Heaton, C. W. Lehmann, J. A. K. Howard, N. Robertson, A. E. Underhill, and I. F. Perepichka, *J. Mater. Chem.*, **8**, 1541 (1998).

(4) H. Suzuki, H. Itoh, E. Ogura, Y. Kuwatani, H. Matsuyama, and M. Iyoda, *Abstracts of 70th Annual Meeting of the Chemical Society of Japan II*, 3G4 (1996).

(5) L. M. Goldenberg, J. Y. Becher, O. P. Levi, V. Y. Khodorkovsky, M. R. Bryce, and M. C. Petty, *J. Chem. Soc., Chem. Commun.*, 475 (1995).

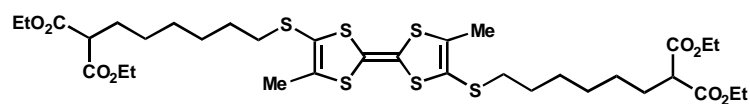
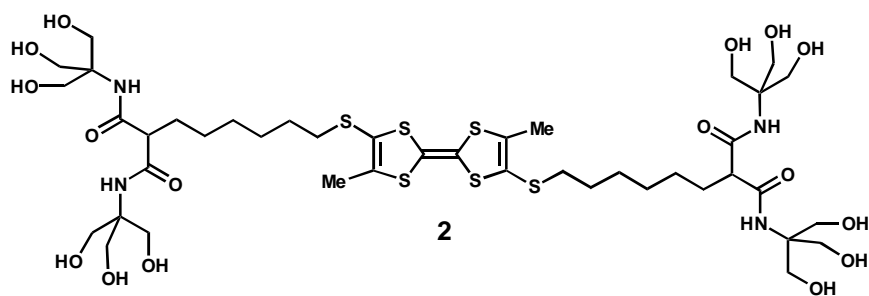


R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
(CH ₂) ₄ Cl	68-70	CHCl ₃	0.51	0.86	CH ₂ Cl ₂	0.1M TBAHP	1
(CH ₂) ₅ Cl	oil	CHCl ₃	0.50	0.85	CH ₂ Cl ₂	0.1M TBAHP	1
(CH ₂) ₂ O(CH ₂) ₂ Cl	oil	CHCl ₃	0.49	0.82	CH ₂ Cl ₂	0.1M TBAHP	1
(CH ₂) ₄ I	54-55	CHCl ₃	0.51	0.76	CH ₃ CN	0.1M TBAHP	1
(CH ₂) ₅ I	oil	CHCl ₃	0.51	0.76	CH ₃ CN	0.1M TBAHP	1
(CH ₂) ₂ O(CH ₂) ₂ I	oil	CHCl ₃	0.46	0.71	CH ₃ CN	0.1M TBAHP	1
S(CH ₂) ₂ CN							2

^aSolvent for ¹HNMR.

(1) K. B. Simonsen, K. Zong, R. D. Rogers, and M. P. Cava, *J. Org. Chem.*, **62**, 679 (1997).

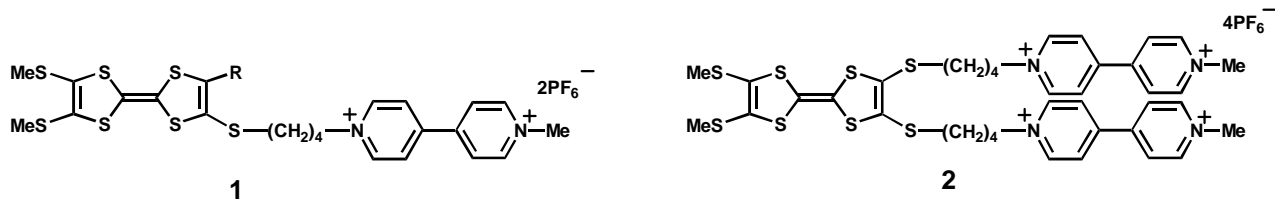
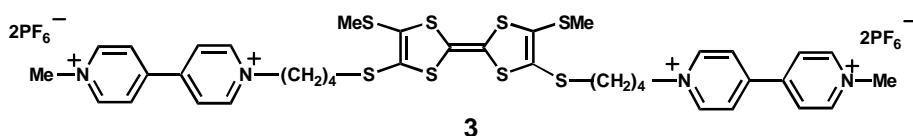
(2) J. Becher, J. Lau, P. Leriche, P. Mørk, and N. Svenstrup, *J. Chem. Soc., Chem. Commun.*, 2715 (1994).

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	mp/°C	solubility ^{a)}	<i>E</i> ₁	<i>E</i> ₂	CV (vs. SCE)	reference
1	55-57	CHCl ₃				1
2	145-150	DMSO	0.46	0.78	CH ₃ CN	1

^aSolvent for ¹HNMR.

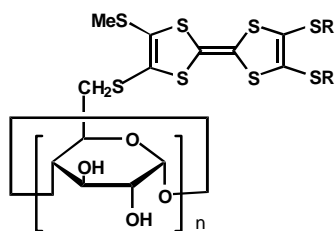
(1) M. Jørgensen, K. Bechgaard, T. Bjørnholm, P. Sommer-Larsen, L. G. Hansen, and K. Schaumburg, *J. Org. Chem.*, **59**, 5877 (1994).

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	R	mp/°C	solubility ^{a)}	<i>E</i> ₁	<i>E</i> ₂	<i>E</i> ₃	<i>E</i> ₄	(vs. SCE)	reference	
1	SCH ₃	186 (dec.)	DMSO	-0.83	-0.39	0.52	0.77	CH ₃ CN	0.1M TBAHP	1
	S(CH ₂) ₃ CH ₂ I	180 (dec.)	DMSO	-0.83	-0.39	0.53	0.78	CH ₃ CN	0.1M TBAHP	1
2			DMSO	-0.84	-0.39	0.53	0.78	CH ₃ CN	0.1M TBAHP	1
3			DMSO	-0.85	-0.38	0.53	0.78	CH ₃ CN	0.1M TBAHP	1

^aSolvent for ¹HNMR.

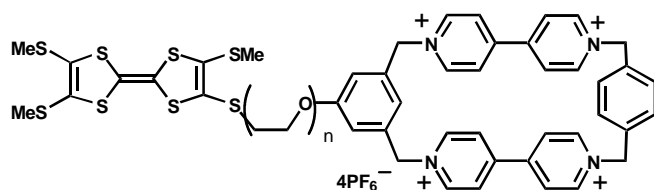
(1) K. B. Simonsen, K. Zong, R. D. Rogers, and M. P. Cava, *J. Org. Chem.*, **62**, 679 (1997).



n	R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
7	CH ₃		CH ₂ Cl ₂ -MeOH-AcOH				1
7	C ₅ H ₁₃		CH ₂ Cl ₂ -MeOH-AcOH				1
7	C ₈ H ₁₇		CH ₂ Cl ₂ -MeOH-AcOH				1
8	CH ₃		CH ₂ Cl ₂ -MeOH-AcOH				1

^aSolvent for chromatography.

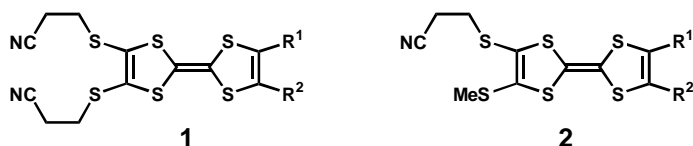
(1) M. Sallé, Y. Le Bras, R. Andreu, P. Leriche, C. Mingotaud, and A. Gorgues, *Synth. Met.*, **94**, 47 (1998).



n	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1		CH ₃ CN				1
3		CH ₃ CN				1

^aSolvent for ¹HNMR.

(1) M. B. Nieslsen, S. B. Nielsen, and J. Becher, *Chem. Commun.*, 475 (1998).

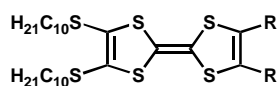


	R ¹	R ²	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. Ag / AgCl)	reference
1	SCH ₃	SC ₁₈ H ₃₇	104-105	EtOH ^{b)}	0.59	0.98	CH ₂ Cl ₂	TEAHP 1
2	S(CH ₂) ₂ CN	S(CH ₂) ₂ CN	146-148	CH ₂ Cl ₂ -ether ^{b)}	0.58	0.89	CH ₂ Cl ₂	TEAHP 1
	SCH ₃	SCH ₃	102-104	^{b, d)}	0.57	0.92	CH ₂ Cl ₂	TEAHP 1
	SC ₂ H ₅	SC ₂ H ₅	81-82	CHCl ₃	0.56	0.91	CH ₂ Cl ₂	TEAHP 1
	-S(CH ₂) ₂ S-		109-110	CH ₂ Cl ₂ -ether ^{b)}	0.57	0.92	CH ₂ Cl ₂	TEAHP 1
	S(CH ₂) ₂ Ph	S(CH ₂) ₂ Ph	129-129.5	CH ₂ Cl ₂ -ether ^{b)}	0.55	0.87	CH ₂ Cl ₂	TEAHP 1

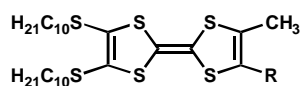
SC ₅ H ₁₁	SC ₅ H ₁₁	84	CH ₂ Cl ₂ -ether ^{c)}	0.55	0.89	CH ₂ Cl ₂	TEAHP	1
SC ₁₀ H ₂₁	SC ₁₀ H ₂₁	92	CHCl ₃	0.55	0.89	CH ₂ Cl ₂	TEAHP	1
SC ₁₈ H ₃₇	SC ₁₈ H ₃₇	95-96	CHCl ₃ ^{c)}	0.58	0.88	CH ₂ Cl ₂	TEAHP	1
SCH ₃	SC ₁₈ H ₃₇	89-90	CH ₂ Cl ₂ -ether ^{c)}	0.54	0.89	CH ₂ Cl ₂	TEAHP	1
CO ₂ Me	CO ₂ Me	78-79	CHCl ₃	0.7	1.01	CH ₂ Cl ₂	TEAHP	1
S(CH ₂) ₂ CN	SCH ₃ (<i>cis/trans</i>)							1
S(CH ₂) ₂ Ph	SCH ₃		CHCl ₃ -ether ^{b)}					1

^aSolvent for ¹HNMR. ^bSolvent for recrystallization. ^cSolvent for chromatography. ^dToluene-cyclehexane.

(1) K. B. Simonsen, N. Svensrup, J. Lau, O. Simonsen, P. Mørk, G. J. Kristensen, and J. Becher, *Synthesis*, 407 (1996).



1

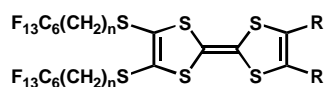


2

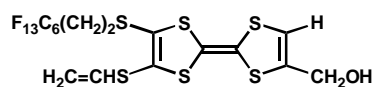
	R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
1	COOH	175-177	CHCl ₃				1
	COOCH ₃	oil	CHCl ₃				1
	SCH ₂ COOH	126-129 (dec.)	DMSO				1
	SCH ₂ COOCH ₃	67-69	CHCl ₃				1
2	S(CH ₂) ₃ COOH	74-75	CHCl ₃				1
	S(CH ₂) ₃ COOCH ₃	38-40	CHCl ₃				1
	S(CH ₂) ₃ CN	66-69	CHCl ₃				1
	S(CH ₂) ₃ NH ₂	110-111	CHCl ₃				1

^aSolvent for ¹HNMR.

(1) R. P. Parg, J. D. Kilburn, M. C. Petty, C. Pearson, and T. G. Ryan, *Synthesis*, 613 (1994).



1



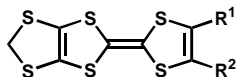
2

	n	R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
1	2	CO ₂ CH ₃		CH ₂ Cl ₂	0.82	1.17	CH ₂ Cl ₂	TBAHP
	2	-S(CH ₂) ₂ S-		CH ₂ Cl ₂	0.65	1.00	CH ₂ Cl ₂	TBAHP
	11	SCH ₂ COOCH ₃	70.5-71	heptane ^{b)}				2
2				CH ₂ Cl ₂	0.51	0.93	CH ₂ Cl ₂	TBAHP

^aSolvent for CV. ^bSolvent for preparation of LB film.

(1) T. Nozdryn, J. Cousseau, R. Andreu, M. Sallé, A. Guy, J. Roncali, A. Gorgues, M. Jubault, S. Uriel, J. Orduna, and J. Garín, *Synth. Met.*, **70**, 1159 (1995).

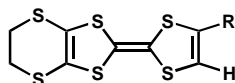
(2) E. Dupart, B. Agricole, S. Ravaine, C. Mingotaud, O. Fichet, P. Delhaes, H. Ohnuki, G. Munger, and R. M. Leblanc, *Thin Solid Films*, **243**, 575 (1994).

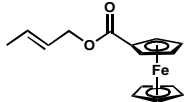


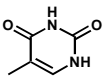
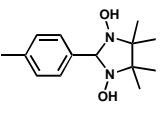
R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
H	I						1
H	COOCH ₃	193	CH ₃ CN				2
SCH ₃	SC ₁₈ H ₃₇	46-49	CH ₃ CN				3
SCH ₃	S(CH ₂) ₈ OH	oil	CH ₃ CN				3

^aSolvent for UV.

- (1) T. Imakubo, H. Sawa, and R. Kato, *Abstracts of Symposium on Molecular Structure*, 2B23 (1995).
 (2) G. C. Papavassiliou, J. S. Zambounis, G. A. Mousdis, V. Gionis, and S. Y. Yiannopoulos, *Mol. Cryst. Liq. Cryst.*, **156**, 269 (1988).
 (3) J. S. Zambounis, C. W. Mayer, *Tetrahedron Lett.*, **32**, 2737 (1991).



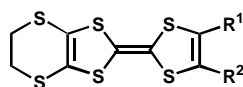
R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
CH ₃			0.41	0.75	0.1M TBAP	1
CH ₂ OH	121-123	CHCl ₃ -ether ^{b)}	0.52	0.7	DMF 0.1M TBAP	2
C ₁₆ H ₃₃		hexane-CHCl ₃ ^{c)}				3, 4
CH=CHCH ₂ OH						14
		CH ₂ Cl ₂ ^{f)}	0.51 0.96	0.73 (E ₃)	CH ₂ Cl ₂ 0.1M TBAHP	14
CH=CHCO ₂ CH ₃						14
CH=CHCHO		CHCl ₃				14
-(CH ₂) ₃ C CH						5
-(CH ₂) ₈ C CH						5
-(CH ₂) ₃ C C-C C(CH ₂) ₁₁ CH ₃	43-45	CHCl ₃	0.48	0.68	DMF	^{e)} 5
-(CH ₂) ₈ C C-C C(CH ₂) ₄ CH ₃	72-74	CHCl ₃	0.48	0.68	DMF	^{e)} 5
-(CH ₂) ₈ C C-C C(CH ₂) ₁₁ CH ₃	52-54	CH ₂ Cl ₂	0.48	0.68	DMF	^{e)} 5
COOH	216-217(dec.)	DMSO ^{a)}				11
COOCH ₃	193	CH ₃ CN ^{c)}				6
CH ₂ C(O)OC ₁₇ H ₃₅						7
C(O)O(CH ₂) ₂ C ₆ F ₁₃			0.63	1.08	CH ₂ Cl ₂ 0.1M TBAHP	^{e)} 13
CHO	152-153	CHCl ₃	0.59	0.91	CH ₃ CN 0.1M TBAHP	^{e)} 8
C(O)Cl	165-168(dec.)	CHCl ₃ ^{a)}				
C(O)NH ₂	214-215(dec.)	THF ^{b)}	0.49	0.81	CH ₃ CN 0.05M TBAHP	11
C(O)NHMe	216-217	CH ₃ CN ^{b)}	0.5	0.82	CH ₃ CN 0.05M TBAHP	11
C(O)NMe ₂	177-178	CH ₃ CN ^{b)}	0.47	0.8	CH ₃ CN 0.05M TBAHP	11
C(O)NHNH ₂	194-195	acetone ^{b)}	0.48	0.88	CH ₃ CN 0.05M TBAHP	11

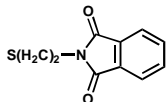
C(S)NHCH ₃	185-186	CS ₂	0.53	0.86	CH ₃ CN	TBAT	9
							12
C ₆ H ₄ CHO ^p		CHCl ₃					15
		DMSO					15
Cl	174-176	CHCl ₃ -CS ₂	0.57	0.88	PhCN	0.1M TBAP	10
Br	113-114	CHCl ₃ -CS ₂	0.56	0.88	PhCN	0.1M TBAP	10
I	119-120	CHCl ₃ -CS ₂	0.553	0.85	PhCN	0.1M TBAP	10

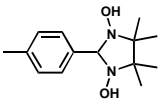
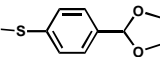
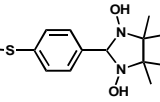
^aSolvent for ¹HNMR. ^bSolvent for recrystallization. ^cSolvent for preparation of LB film. ^dSolvent for UV.

^eV vs. Ag / AgCl. ^fSolvent for CV.

- (1) V. Yu. Khodorkovskii, A. Edžifna, and O. Neilands, *J. Mol. Electronics*, **5**, 33 (1989).
- (2) Ph. Blanchard, M. Sallé, G. Duguay, M. Jubault, and A. Gorgues, *Tetrahedron Lett.*, 2685 (1992).
- (3) S. V. Ayrapetiants, T. S. Berzina, S. A. Shikin, and V. I. Troitsky, *Thin. Solid. Films.*, **210/211**, 261 (1992).
- (4) F. Rustichelli, S. Dante, P. Mariani, I. V. Myagkov, and V. I. Troitsky, *Thin Solid Films*, **242**, 267 (1994).
- (5) V. Yu. Khodorkovsky, G. V. Tormos, O. Ya. Neilands, N. V. Kolotilo, and A. Ya. Il'chenko, *Tetrahedron Lett.*, **33**, 973 (1992).
- (6) G. C. Papavassiliou, J. S. Zambounis, G. A. Mousdis, V. Gionis, and S. Y. Yiannopoulos, *Mol. Cryst. Liq. Cryst.*, **156**, 269 (1988).
- (7) L. M. Goldenberg, R. Andreu, M. Savirón, A. J. Moore, J. Garín, M. R. Bryce, and M. C. Petty, *J. Mater. Chem.*, **5**, 1593 (1995).
- (8) J. Garín, J. Orduna, M. Savirón, M. R. Bryce, A. J. Moore, and V. Morisson, *Tetrahedron*, **52**, 11063 (1996).
- (9) A. J. Moore, M. R. Bryce, A. S. Batsanov, J. N. Heaton, C. W. Lehmann, J. A. K. Howard, N. Robertson, A. E. Underhill, and I. F. Perepichka, *J. Mater. Chem.*, **8**, 1541 (1998).
- (10) U. Kux, H. Suzuki, S. Sasaki, and M. Iyoda, *Chem. Lett.*, 183 (1995).
- (11) K. Heuzé, M. Fourmigue, and P. Batail, *J. Mater. Chem.*, **9**, 2373 (1999).
- (12) S. Maki, Y. Morita, and K. Nkasuji, *Abstracts of 70th Annual Meeting of the Chemical Society of Japan II*, 3 PA 152 (1999).
- (13) J. Garín, J. Orduna, T. Sierra, R. Andreu, J. Cousseau, T. Nozdryn, *Synth. Met.*, **102**, 1637 (1999).
- (14) R. Andreu, J. Garín, J. Orduna, M. Savirón, and S. Uriel, *Tetrahedron Lett.*, **36**, 4319 (1995).
- (15) J. Nakazaki, M. M. Matsushita, A. Izuoka, and T. Sugawara, *Tetrahedron Lett.*, **40**, 5027 (1999).

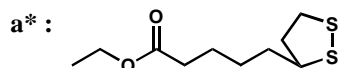


R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
CHO	CH(OC ₂ H ₅) ₂						1
CH ₂ OH	COOCH ₃						1
SCH ₃	S(CH ₂) ₂ CN			^{f)}		CH ₂ Cl ₂ 0.1M TBAHP	7
SCH ₃	S(CH ₂) ₂ OH	80-81	CH ₂ Cl ₂ ^{d)}	^{f)}		CH ₂ Cl ₂ 0.1M TBAHP	7, 8
SCH ₃	S(CH ₂) ₂ OSO ₂ Me	oil					8
SCH ₃		oil	CH ₂ Cl ₂ -hexane ^{d)}				8
SCH ₃	S(CH ₂) ₂ NH	semisolid	CH ₂ Cl ₂ -MeOH ^{d)}				8
SCH ₃	S(CH ₂) ₈ OH	oil	CH ₃ CN				2
SCH ₃	SC ₁₇ H ₃₅	46-49	CH ₃ CN				2

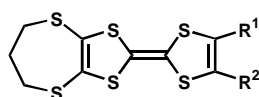
SCH ₃	SCH ₂ CH ₂ COOEt	oil	CH ₂ Cl ₂ -hexane ^{d)}					6
SCH ₃	SCH ₂ CONH ₂	139	CHCl ₃ ^{b)}	0.51	0.84	CH ₂ Cl ₂	0.1M TBAP ^{c)}	5, 6
SCH ₃	SCH ₂ C(O)ONH							3
SCH ₃	SC ₆ H ₄ CHO ^p							6
SCH ₃	C ₆ H ₄ CHO ^p		CHCl ₃ ^{b)}					9
SCH ₃			DMSO ^{b)}					9
SCH ₃								9
SCH ₃	S'C ₆ H ₄ CHO ^p		CHCl ₃ ^{b)}					9
SCH ₃			DMSO ^{b)}					9
a*	C(O)OMe		CHCl ₃ ^{e)}	0.73	0.96	THF	0.1M TBAP ^{c)}	4

^aSolvent for UV. ^bSolvent for ¹H-NMR. ^cV vs Ag / AgCl. ^dSolvent for column chromatography.

^eSolvent for recrystallization. ^f0.44V < E1 < 0.59V and 0.78V < E2 < 0.92V



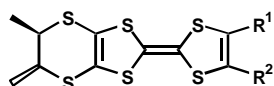
- (1) Ph. Blanchard, M. Sallé, G. Duguay, M. Jubault, and A. Gorgues, *Tetrahedron Lett.*, **33**, 2685 (1992).
- (2) J. S. Zambounis, and C. W. Mayer, *Tetrahedron Lett.*, **32**, 2737 (1991).
- (3) G. Ono, M. Matsushita, T. Sugawara, *Abstracts of Symposium on Molecular Structure*, 3bP79 (1994).
- (4) H. Liu, S. Liu, and L. Echevoyan, *Chem. Commun.*, 1493 (1999).
- (5) G. Ono, M. Matsushita, H. Terao, A. Izuoka, T. Sugawara, and T. Mochida, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 4 C5 08 (1999).
- (5) J. Nakazaki, A. Izuoka, and T. Sugawara, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 3 PA 137 (1999).
- (6) G. Ono, A. Izuoka, T. Sugawara, and Y. Sugawara, *J. Mater. Chem.*, **8**, 1703 (1998).
- (7) J. Legros, F. Dahan, L. Binet, J. Fabre, *Synth. Met.*, 102, 1632 (1999).
- (8) L. Binet, J. Fabre, *Synthesis*, 1179 (1997).
- (9) J. Nakazaki, M. M. Matsushita, A. Izuoka, and T. Sugawara, *Tetrahedron Lett.*, **40**, 5027 (1999).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
H	COOCH ₃		CH ₃ CN				1
H	C ₁₆ H ₃₃		hexane-CHCl ₃ ^{b)}				2, 3

^aSolvent for UV. ^bSolvent for preparation of LB film.

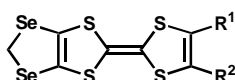
- (1) G. C. Papavassiliou, J. S. Zambounis, G. A. Mousdis, V. Gionis, and S. Y. Yiannopoulos, *Mol. Cryst. Liq. Cryst.*, **156**, 269 (1988).
- (2) S. V. Ayrapetiants, T. S. Berzina, S. A. Shikin, and V. I. Troitsky, *Thin Solid Films*, **210/211**, 261 (1992).
- (3) F. Rustichelli, S. Dante, P. Mariani, I. V. Myagkov, and V. I. Troitsky, *Thin Solid Films*, **242**, 267 (1994).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
SCH ₂ CH ₂ Br	CH ₂ O(CH ₂) ₂ Si(CH ₃) ₃	76-78	CH ₃ CN				1

^aSolvent for UV.

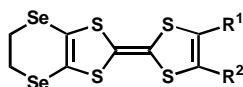
(1) J. S. Zambounis, and C. W. Mayer, *Tetrahedron Lett.*, **32**, 2737 (1991).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
H	COOCH ₃	210	CHCl ₃				1

^aSolvent for ¹HNMR.

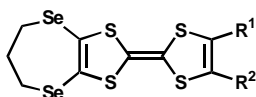
(1) G. C. Papavassiliou, V. C. Kakoussis, J. S. Zambounis, and G. A. Mousdis, *Chem. Scr.*, **29**, 123 (1989).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
H	CHO	159-163	CHCl ₃	0.55	0.85	MeCN-CHCl ₃ 0.1M TBAHP	1
H	COOCH ₃	220	CH ₂ Cl ₂				1
H	CH ₂ OH	126	CH ₂ Cl ₂ -pentane ^{b)}	0.41	0.73	CH ₃ CN 0.1M TBAHP	1
H	CH ₂ OC(O)C ₁₇ H ₃₅						1

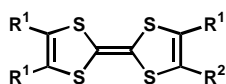
^aSolvent for ¹HNMR. ^bSolvent for recrystallization.

(1) J. Garín, J. Orduna, M. Savirón, M. R. Bryce, A. J. Moore, and V. Morisson *Tetrahedron*, **52**, 11063 (1996).



R ¹	R ²	mp/°C	solubility	E ₁	E ₂	CV (vs. SCE)	reference
H	COOCH ₃						1

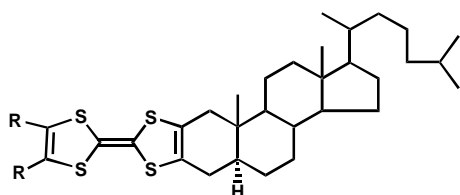
(1) G. C. Papavassiliou, V. C. Kakoussis, J. S. Zambounis, and G. A. Mousdis, *Chem. Scr.*, **29**, 123 (1989).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. Ag / AgCl)	reference	
SePh	H	84					1	
TeCH ₃	H	82-84	CHCl ₃				4	
Br	H	146.5-148	hexane				3	
CO ₂ Me	SCH ₂ CH ₂ CN	168-169	MeOH	0.76	1.08	CH ₃ CN	0.1M TBAHP	2
CO ₂ Me	S ⁻ Cs ⁺	172-175	CH ₃ CN-Et ₂ O					2

^{a)}Solvent for recrystallization.

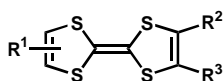
- (1) J. Besancon, J. Padiou, and J. Szymoniak, *C. R. Acad. Sci. Paris, Ser. II*, **313**, 1395 (1991).
- (2) J. Lau, O. Simonsen, and J. Becher, *Synthesis*, 521 (1995).
- (3) J. Nakayama, N. Toyoda, and M. Hoshino, *Heterocycles*, **24**, 1145 (1986).
- (4) K. Tsutsui, K. Takimiya, Y. Aso, and T. Otsubo, *Tetrahedron Lett.*, **38**, 7569 (1997).



n	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
CH ₃	224 (dec.)	CHCl ₃	0.23	0.77	CH ₂ Cl ₂ 0.1M TBAP	1
-S(CH ₂) ₂ S-	248(dec.)	MeOH-CHCl ₃ ^{b)}	0.38	0.85	CH ₂ Cl ₂ 0.1M TBAP	1
SCH ₂ CH ₂ OH	177-178	CHCl ₃	0.40	0.80	CH ₂ Cl ₂ 0.1M TBAP	1
SCH ₂ CH ₂ CN	glass	CHCl ₃	0.49	0.94	CH ₂ Cl ₂ 0.1M TBAP	1

^{a)}Solvent for ¹HNMR. ^{b)}Solvent for recrystallization.

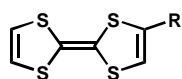
- (1) M. P. Cava, J. Lau, K. B. Simonsen, and J. Becher, *J. Org. Chem.*, **62**, 6814 (1997).



R ¹	R ²	R ³	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
CO ₂ Bu	CO ₂ Bu	CO ₂ Me		CHCl ₃	0.76	1.14	CH ₃ CN 0.1M TBAP ^{a)}	1, 2
CO ₂ Bu	CO ₂ Bu	CO ₂ Et		CHCl ₃	0.75	1.05	CH ₃ CN 0.1M TBAP ^{a)}	1, 2
CO ₂ Bu	CO ₂ Bu	I	87-89	CHCl ₃	0.71	1.01	CH ₃ CN 0.1M TBAP ^{a)}	1, 2
SCH ₃	CH ₃	SCH=CH ₂						3

^{a)}Solvent for ¹HNMR.

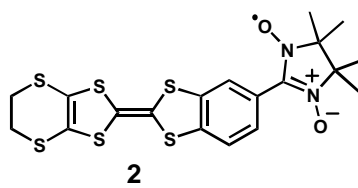
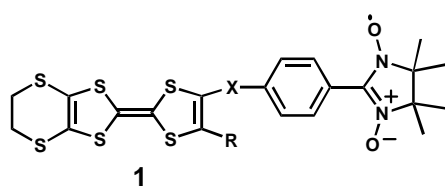
- (1) V. Yu. Khodorkovskii, A. Edžifna, and O. Neilands, *J. Mol. Electronics*, **5**, 33 (1989).
- (2) Ya. N. Kreitsberga, A. S. Édzhinya, R. B. Kampare, and O. Ya. Neiland, *J. Org. Chem. USSR*, **25**, 1312 (1989).
- (3) M. Iyoda, H. Suzuki, and U. Kux, *Tetrahedron. Lett.*, **36**, 8259 (1995).



R	mp/°C	solubility ^{a)}	E_1	E_2	E_3	CV (vs. SCE)	reference
		<i>n</i> -heptane	0.57	0.88	0.92	CH ₂ Cl ₂ TBAT	1, 2
		<i>n</i> -heptane	0.56	0.90	0.92	CH ₂ Cl ₂ TBAT	2
	77.9 (dec.)	MTHF	0.32	0.77	1.00	CH ₂ Cl ₂ 0.1M TBAP	3
	>175 (dec.)	benzene	0.44	0.85		CH ₃ CN	4
	>172 (dec.)	benzene	0.44	0.88		CH ₂ Cl ₂	4
		benzene	0.44	0.79		CH ₂ Cl ₂ 0.1M TBAP ^{b)}	5

^aSolvent for ESR. ^bV vs. Ag / AgCl.

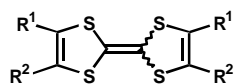
- (1) T. Sugano, T. Fukasaka, and M. Kinoshita, *Synth. Met.*, **41-43**, 3281 (1991).
- (2) T. Sugimoto, S. Yamaga, M. Nakai, K. Ohmori, M. Tsujii, H. Nakatsuji, H. Fujita, and J. Yamauchi, *Chem. Lett.*, 1361 (1993).
- (3) R. Kumai, M. M. Matsushita, A. Izuoka, and T. Sugawara, *J. Am. Chem. Soc.*, **116**, 4523 (1994).
- (4) S. Nakatsuji, S. Satoki, K. Suzuki, T. Enoki, N. Kinoshita, and H. Anzai, *Synth. Met.*, **71**, 1819 (1995).
- (5) J. Nakazaki, M. M. Matsushita, A. Izuoka, and T. Sugawara, *Tetrahedron Lett.*, **40**, 5027 (1999).



R	X	mp/°C	solubility ^{a)}	E_1	E_2	E_3	CV (vs. Ag / AgCl)	reference
1	H	none	benzene	0.54	0.88		CH ₂ Cl ₂ 0.1M TBAP	1
	SCH ₃	none	benzene	0.62	0.92	0.94	CH ₂ Cl ₂ 0.1M TBAP	1
	SCH ₃	S	benzene	0.68	0.97	0.99	CH ₂ Cl ₂ 0.1M TBAP	1
2				0.62	0.9	1.04	PhCN 0.1M TBAP	2

^aSolvent for ESR.

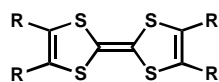
- (1) J. Nakazaki, M. M. Matsushita, A. Izuoka, and T. Sugawara, *Tetrahedron Lett.*, **40**, 5027 (1999).
- (2) J. Nakazaki, Y. Ishikawa, A. Izuoka, and T. Sugawara, *Abstracts of Symposium on Molecular Structure*, 3A10 (1999).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
H			benzene ^{b)}	0.40	0.86	CH ₃ CN TBAP	1
CH(OEt) ₂		E	CH ₂ Cl ₂	0.65		CH ₂ Cl ₂	1
		Z	CH ₂ Cl ₂	0.60		CH ₂ Cl ₂	1

^aSolvent for CV. ^bSolvent for ESR.

(1) S. Nkatsuji, and H. Anzai, *J. Mater. Chem.*, **7**, 2161 (1997).

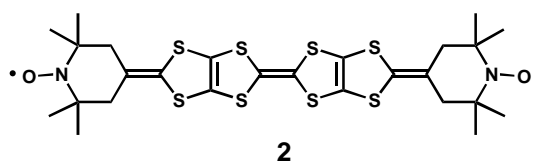
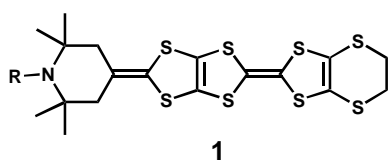


R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
		CH ₂ Cl ₂	0.55		CH ₂ Cl ₂	1
						2

^aSolvent for CV. ^bSolvent for ESR.

(1) S. Nkatsuji, and H. Anzai, *J. Mater. Chem.*, **7**, 2161 (1997).

(2) T. Jin, A. Izuoka, and T. Sugawara, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 3PA139 (1996).

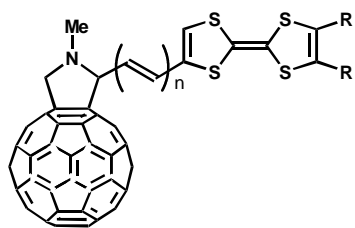


R	mp/°C	solubility ^{a)}	E ₁	E ₂	E ₃	E ₄	CV (vs. Ag / AgCl)	reference	
1	O •	206-207 (dec.)	benzene	0.56	0.88	1.17	1.77	PhCN	1
	H			0.55	0.87	1.74		PhCN	1
2									2

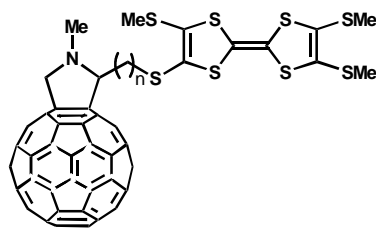
^aSolvent for ESR.

(1) H. Fujiwara, and H. Kobayashi, *Chem. Commun.*, 2417 (1999).

(2) H. Fujiwara, and H. Kobayashi, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan I*, 2E701 (1999).



1



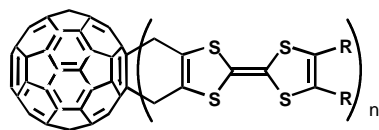
2

	R	n	mp/°C	solubility ^{a)}	E_1^{ox}	E_2^{ox}	E_1^{red}	E_2^{red}	E_3^{red}	E_4^{red}	(vs. SCE)	reference
1	H	0		CHCl ₃	0.41	0.76	-0.67	-1.04	-1.53	-2.05	b)	0.1M TBAP 1
	S(CH ₂) ₂ S	0		CHCl ₃	0.50	0.78	-0.71	-1.05	-1.56	-2.10	b)	0.1M TBAP 1
	H	1		CHCl ₃	0.43	0.76	-0.67	-1.08	-1.58	-2.19	b)	0.1M TBAP 1
	S(CH ₂) ₂ S	1		CHCl ₃	0.54	0.78	-0.71	-1.19	-1.61	-2.20	b)	0.1M TBAP 1
2		3		CHCl ₃	0.50	0.86	-0.72	-1.11			CH ₂ Cl ₂	0.1M TBAHP 2
		10		CHCl ₃	0.51	0.85	-0.70	-1.08			CH ₂ Cl ₂	0.1M TBAHP 2

^aSolvent for ¹HNMR. ^bCH₃CN-toluene.

(1) N. Martín, L. Sánchez, C. Seoane, R. Andreu, J. Garín, and J. Orduna, *Tetrahedron Lett.*, **37**, 5979 (1996).

(2) K. B. Simonsen, V. V. Konovalov, T. A. Konovalova, T. Kawai, M. P. Cava, L. D. Kispert, R. M. Metzger, and J. Becher, *J. Chem. Soc., Perkin Trans. 2*, 657 (1999).



R	n	mp/°C	solubility ^{a)}	E_1^{ox}	E_2^{ox}	E_1^{red}	E_2^{red}	E_3^{red}	E_4^{red}	CV (vs. Ag / Ag ⁺)	reference
CO ₂ CH ₃	1		CS ₂ -CHCl ₃	0.21	0.69	-1.04	-1.43	-1.96		CH ₂ Cl ₂	0.1M TBAHP 1, 2
				0.13	0.65	-1.21	-1.63	-1.99	-2.57	o-DCB	0.1M TBAHP 1
H	1		CS ₂ -o-DCB	-0.04	0.46	-1.08	-1.47	-1.98		CH ₂ Cl ₂	0.1M TBAHP 1
				-0.08	0.43	-1.17	-1.53	-2.05	-2.49	o-DCB	0.1M TBAHP 1
CH ₃	1		o-DCB	-0.1	0.41	-1.08	-1.45	-1.96		CH ₂ Cl ₂	0.1M TBAHP 1
				-0.15	0.41	-1.18	-1.55	-2.06	-2.52	o-DCB	0.1M TBAHP 1
SCH ₃	1		o-DCB	0.6	1.04	-0.76	-1.15	-1.65	-1.92	o-DCB	0.1M TBAHP 3
CO ₂ CH ₃	2		CS ₂ -CH ₂ Cl ₂	0.17	0.64	-1.16	-1.52	-1.95		CH ₂ Cl ₂	0.1M TBAHP 1
				0.13	0.58	-1.27	-1.64	-2.02	-2.41	o-DCB	0.1M TBAHP 1
SCH ₂ CH ₂ CN	1			0.59	0.2	-1.16	-1.79	-2.32		o-DCB	4

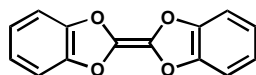
^aSolvent for ¹HNMR.

(1) J. Llacay, J. Veciana, J. V-Gancedo, J. L. Bourdelande, R. G-Moreno, and C. Rovira, *J. Org. Chem.*, **63**, 5201 (1998).

(2) J. Llacay, M. Mas, E. Molins, J. Veciana, D. Powell and C. Rovira, *Chem. Commun.*, 659 (1997).

(3) C. Boule, J. M. Rabreau, P. Hudhomme, M. Cariou, M. Jubault, A. Gorgues, J. Orduna, and J. Garín, *Tetrahedron Lett.*, **38**, 3909 (1997).

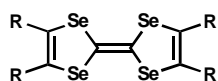
(4) M. Taniguchi, Y. Misaki, and K. Tanaka, *Abstract of 76th Annual Meeting of the Chemical Society of Japan II*, 3PA150 (1999).




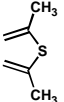
mp/°C	solubility	E_1	E_2	CV (vs. Ag / Ag ⁺)	reference
>145(dec.)	<i>o</i> -DCB ^{a)}	0.584 ^{b)}		<i>o</i> -DCB 0.1M TBAP	1

^{a)}Solvent for CV. ^{b)}Irreversible wave.

(1) K. Tanaka, K. Kadoto, K. Yoshida, A. Kobayashi, N. Ishida, and T. Nogami, *Abstracts of Symposium Molecular Structure*, 2A05 (1999).



R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
H	132.5-133	CHCl ₃	0.48	0.76	CH ₃ CN 0.1M TBAP	1, 2, 3, 4
CH ₃	>250 (dec.)	CH ₂ Cl ₂ ^{c)}	0.167		CH ₂ Cl ₂	5
		PhCN ^{c)}	0.42	0.81	PhCN TBAHA	6
		CH ₂ Cl ₂ ^{d)}	0.43	0.73	CH ₂ Cl ₂ 0.1M TBAT	7
		CHCl ₃ ^{b)}	0.43	0.73	CH ₂ Cl ₂ 0.1M TBAT	7
CD ₃	150-151	ⁿ BuCN ^{c)}	0.18	0.45	ⁿ BuCN 0.1M TBAT ^{b)}	8
		CH ₂ Cl ₂ ^{b)}	0.55	0.94	CH ₂ Cl ₂ 0.1M TEAP	9
CH ₂ OH	247 (dec.)	DMSO	0.48	0.70	DMF 0.1M TBAP	10
CHO	315 (dec.)	DMSO				10
CH=C(CH ₃) ₂	124.5-126	CCl ₄	0.71	0.89	THF 0.1M TBAP	10
COOH	>300 (dec.)	EtOH ^{d)}				11
COOMe	145 (dec.)	CHCl ₃				11
CONH ₂						12
-(CH=CH) ₂ -	291-293	CHCl ₃	0.78		CH ₂ Cl ₂ 0.1M TBAT	13
	>350					30
	<i>cis</i> 228-230	DMF ^{b)}	0.495		DMF 0.1M LiCl	26
	<i>trans</i> 242-245	DMF ^{b)}	0.49		DMF 0.1M LiCl	26
	<i>cis</i> 235-236	DMF ^{b)}	0.48		DMF 0.1M LiCl	26
	<i>trans</i> 240-243	DMF ^{b)}	0.465		DMF 0.1M LiCl	26
	228-230(dec.)	CH ₃ CN ^{f)}				24

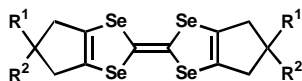
										28
	313-315	CCl ₄ ^{b)}								29
CF ₃	111-112	CHCl ₃ ^{a)}								25
-S(CH ₂) ₂ S-	220 (dec.)	CS ₂								14
		PhCN ^{c)}	0.27	0.49	PhCN	0.1M TBAP ^{b)}				15, 16
-S(CH ₂) ₃ S-		PhCN ^{c)}	0.27	0.51	PhCN	0.1M TBAP ^{b)}				16
SCH ₃	119-119.7	CHCl ₃	0.64	0.84	CH ₃ CN	0.1M TBAP				17
		CH ₃ CN ^{c)}	0.78	1.03	DCE	0.1M TBAT				18
SPh	140 (dec.)	CHCl ₃								11
S-SEM ^{e)}										23
Se-SEM ^{e)}										23
SeCH ₃	112-113	CCl ₄	0.58	0.81	CH ₃ CN	0.1M TEAT				19
	115.2-116.2	CCl ₄	0.62	0.86	CH ₃ CN	0.1M TBAT				17
SeC ₂ H ₅	57-57	CHCl ₃								
		CH ₃ CN ^{c)}	0.75	1.04	DCE	0.1M TBAT				18
-Se(CH ₂) ₂ Se-	>260 (dec.)	CS ₂	0.30	0.55	PhCN	0.1M TBAT ^{b)}				20
-Se(CH ₂) ₃ Se-		PhCN ^{c)}	0.27	0.51	PhCN	0.1M TBAP ^{b)}				21, 16
SeC ₆ H ₅	155 (dec.)	CHCl ₃								11
SiMe ₃	104-105	CHCl ₃ ^{a)}								27
Cl			0.97	1.09	PhCN	0.1M TBAP ^{e)}				22

^{a)}Solvent for ¹HNMR. ^{b)}Solvent for recrystallization. ^{c)}Solvent for CV. ^{d)}Solvent for UV.

^{e)}SEM = CH₂O(CH₂)₂Si(CH₃)₃. ^{f)} Solvent for Mass spectrum

- (1) E. M. Engler, and V. V. Patel, *J. Am. Chem. Soc.*, **13**, 7376 (1974).
- (2) E. M. Engler, F. B. Kaufman, D. C. Green, C. E. Klots, and R. N. Compton, *J. Am. Chem. Soc.*, **97**, 2921 (1975).
- (3) E. M. Engler, B. A. Scott, S. Etemad, T. Penny, and V. V. Patel, *J. Am. Chem. Soc.*, **99**, 5909 (1977).
- (4) B. A. Scott, F. B. Kaufman, and E. M. Engler, *J. Am. Chem. Soc.*, **98**, 4342 (1976).
- (5) K. Bechgaard, D. O. Cowan, and A. N. Bloch, *J. Chem. Soc., Chem. Commun.*, 937 (1974).
- (6) F. Wudl, and E. Aharon-Shalom, *J. Am. Chem. Soc.*, **104**, 1154 (1982).
- (7) F. Wudl, E. Aharon-Shalom, and S. H. Bertz, *J. Org. Chem.*, **46**, 4612 (1981).
- (8) A. B. Bailey, R. D. McCullough, M. D. Mays, D. O. Cowan, and K. A. Lerstrup, *Synth. Met.*, **27**, B 425 (1988).
- (9) E. M. Engler, V. V. Patal, J. E. Andersen, R. R. Schumaker, and A. A. Fukushima, *J. Am. Chem. Soc.*, **100**, 3769 (1978).
- (10) M. Sallé, A. Gorgues, J. M. Fabre, K. Bechgaard, M. Jubault, and F. Texier, *J. Chem. Soc., Chem. Commun.*, 1520 (1989).
- (11) S. Rajeswari, Y. A. Jackson, and M. P. Cava, *J. Chem. Soc., Chem. Commun.*, 1089 (1988).
- (12) J. E. Rice, P. Wojciechowski, and Y. Okamoto, *Heterocycles*, **18**, 191 (1982).
- (13) I. Johannsen, K. Bechgaard, K. Mortensen, and C. Jacobsen, *J. Chem. Soc., Chem. Commun.*, 295 (1983).
- (14) R. R. Schumaker, V. Y. Lee, and E. M. Engler, *J. Phys.*, **44**, C3 1139 (1983).
- (15) R. Kato, and H. Kobayashi, *Synth. Met.*, **41**, 2093 (1991).
- (16) R. Kato, S. Aonuma, Y. Okano, H. Sawa, A. Kobayashi, and H. Kobayashi, *Synth. Met.*, **55-57**, 2084 (1993).
- (17) N. Iwasawa, G. Saito, K. Imaeda, T. Mori, and H. Inokuchi, *Chem. Lett.*, 2399 (1987).
- (18) N. Iwasawa, H. Urayama, H. Yamochi, G. Saito, K. Imaeda, T. Mori, Y. Maruyama, H. Inokuchi, T. Enoki, Y. Higuchi, and N. Yasuoka, *Synth. Met.*, **27**, B 463 (1988).
- (19) E. M. Engler, D. C. Greene, and J. Q. Chambers, *J. Chem. Soc., Chem. Commun.*, 148 (1976).
- (20) V. Y. Lee, *Synth. Met.*, **20**, 161 (1987).
- (21) R. Kato, H. Kobayashi, A. Kobayashi, *Synth. Met.*, **19**, 629 (1987).
- (22) Y. Kataoka, A. Morikami, K. Takimiya, Y. Aso, and T. Otsubo, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 4 C5 05 (1999).

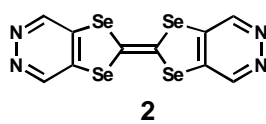
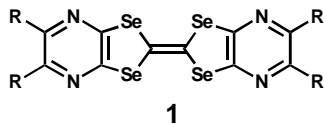
- (23) J. S. Zambounis, and C. W. Mayer, *Tetrahedron. Lett.*, **32**, 2741 (1991).
 (24) C. Berg, K. Bechgaard, J. R. Andersen, and C. S. Jacobsen, *Tetrahedron Lett.*, **20**, 1719 (1976).
 (25) E. M. Engler, and V. V. Patel, *J. Chem. Soc., Chem. Commun.*, 835 (1977).
 (26) E. Fnaghänel, G. Schukat, and J. Schützendübel, *Z. Chem.*, **21**, 447 (1981).
 (27) Y. Okamoto, H. S. Lee, and S. T. Attarwala, *J. Org. Chem.*, **50**, 2788 (1985).
 (28) L. Chiang, P. Shu, D. Holt, and D. Cowan, *J. Org. Chem.*, **48**, 4713 (1983).
 (29) K. Lerstrup, M. Lee, D. Cowan, T. Kistenmacher, *Mol. Cryst. Liq. Cryst.*, **120**, 295 (1985).
 (30) I. Johannsen, K. Bechgaard, K. Mortensen, and C. Jacobsen, *J. Chem. Soc., Chem. Commun.*, 295 (1983).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)		reference
CH ₃	H (<i>syn</i>)	181-184	hexane ^{b)}	0.48	0.75	CH ₂ Cl ₂	0.1M TEAP	1
CH ₃	H		<i>n</i> BuCN	0.15	0.39	<i>n</i> BuCN	0.1M TBAT ^{b)}	2
CH ₃	CH ₃		<i>n</i> BuCN	0.16	0.39	<i>n</i> BuCN	0.1M TBAT ^{b)}	3
	-(CH ₂) ₂ -		<i>n</i> BuCN	0.17	0.41	<i>n</i> BuCN	0.1M TBAT ^{b)}	2

^{a)}Solvent for CV. ^{b)}Solvent for recrystallization.

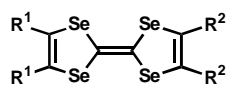
- (1) E. M. Engler, V. V. Patal, J. E. Andersen, R. R. Schumaker, and A. A. Fukushima, *J. Am. Chem. Soc.*, **100**, 3769 (1978).
 (2) A. B. Bailey, R. D. McCullough, M. D. Mays, D. O. Cowan, and K. A. Lerstrup, *Synth. Met.*, **27**, B 425 (1988).
 (3) K. Lerstrup, A. Bailey, R. McCullough, M. Mays, D. Cowan, and T. Kistenmacher, *Synth. Met.*, **19**, 647 (1987).



	R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)		reference
1	H	>309	CH ₃ CN					1
		303	CH ₃ CN					2
	CH ₃	>310	CH ₃ CN					1
	-(CH=CH) ₂ -							2
2		296 (dec.)					3	

^{a)}Solvent for UV.

- (1) G. C. Papavassiliou, S. Y. Yiannopoulos, J. S. Zambounis, K. Kobayashi, and K. Umemoto, *Chem. Lett.*, 1279 (1987).
 (2) G. C. Papavassiliou, S. Y. Yiannopoulos, and J. S. Zambounis, *Mol. Cryst. Liq. Cryst.*, **120**, 333 (1985).
 (3) M. Sallé, A. Gorgues, J. M. Fabre, K. Bechgaard, M. Jubault, and F. Texier, *J. Chem. Soc., Chem. Commun.*, 1520 (1989).

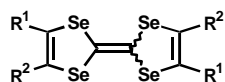


R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)		reference
H	CH ₃	137-138	CHCl ₃	0.52	0.89	TCE	0.1M TBAP	8
H	-(CH ₂) ₃ -	152-153	CS ₂	0.525	0.880	TCE	0.1M TBAP	8

H	-(CH ₂) ₄ -	130	CHCl ₃	0.58	0.955	TCE	0.1M TBAP	1, 2
-(CH ₂) ₃ -	-(CH ₂) ₄ -	223	acetone	0.50	0.90	TCE	0.1M TBAP	1, 2
-(CH ₂) ₄ -	CHO	251	CHCl ₃					3
-(CH ₂) ₄ -	CH ₂ OH	206	CHCl ₃					3
-(CH ₂) ₄ -	CH(OCH ₂ CH ₃) ₂	103	CHCl ₃					3
-(CH ₂) ₄ -	-S(CH ₂) ₂ S-							4
CH ₃	-(CH ₂) ₃ -	257	CS ₂	0.48	0.870	TCE	0.1M TBAP	9
CH ₃	-(CH ₂) ₄ -	212	benzene					1, 2
CH ₃	-S(CH ₂) ₂ S-		CS ₂ ^{b)}	0.15	0.44	PhCN	0.1M TBAP ^{b)}	5
CH ₃	CH(OCH ₂ CH ₃) ₂	79	CHCl ₃	0.47	0.74	CH ₃ CN	0.1M TBAP	3, 6
CH ₃	CHO	259	CHCl ₃	0.7	0.97	CH ₃ CN	0.1M TBAP	3, 6
CH ₃	CH ₂ OH	243	CHCl ₃	0.42	0.71	CH ₃ CN	0.1M TBAP	3, 6
-S(CH ₂) ₂ S-	I							7

^aSolvent for ¹HNMR. ^bSolvent for chromatography.

- (1) J. M. Fabre, A. K. Fouasmia, L. Giral, and D. Chasseau, *Tetrahedron Lett.*, **29**, 2185 (1988).
- (2) J. M. Fabre, A. K. Gouasmia, L. Giral, and M. Galtier, *New. J. Chem.*, **12**, 119 (1988).
- (3) J. M. Fabre, S. Chakroune, L. Giral, A. Gorgues, and M. Sallé, *Synth. Met.*, **55-57**, 2073 (1993).
- (4) H. Isomitsu, K. Kamoshida, H. Sanaga, T. Kondoh, and G. Saito, *Abstracts of 74th Annual Meeting of the Chemical Society of Japan I*, 4J314 (1998).
- (5) R. Kato, S. Aonuma, Y. Okano, H. Sawa, A. Kobayashi, and H. Kobayashi, *Synth. Met.*, **55-57**, 2084 (1993).
- (6) J. M. Fabre, S. Chakroune, A. Gorgues, and L. Ouahab, *Synth. Met.*, **55-57**, 1978 (1993).
- (7) T. Imakubo, H. Sawa, and R. Kato, *Abstracts of Symposium on Molecular Structure*, 2B23 (1995).
- (8) J. M. Fabre, E. Mahnal, and L. Giral, *Synth. Met.*, **13**, 339 (1986).
- (9) J. M. Fabre, L. Giral, E. Dupart, C. Coulon, J. P. Manceau, and P. Delhaes, *J. Chem. Soc., Chem. Commun.*, 1477 (1986).

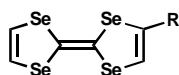


R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference	
H	CH ₃						8	
H	COOH						1	
H	COOCH ₃						1	
H	S-SEM ^{d)}						7	
H	Se-SEM ^{d)}						7	
H	Ph	189-195	CH ₃ CN ^{b)}				6	
H	Cl			0.75	0.98	PhCN	0.1M TBAP ^{c)}	4
H	Br			0.73	0.96	PhCN	0.1M TBAP ^{c)}	4
H	I			0.69	0.94	PhCN	0.1M TBAP ^{c)}	4
CHO	CH(OC ₂ H ₅) ₂ (E)	173-176	CHCl ₃				2	
	CH(OC ₂ H ₅) ₂ (Z)	153-157	CHCl ₃				2	
CH ₃	CH ₂ CH ₃						8	
SCH ₃	CH ₂ CH ₂ OH	110-112	CHCl ₃				3	
SCH ₃	CH ₂ CH ₂ OTs	155 (dec.)	CHCl ₃				3	
SeCH ₃	CH ₂ CH ₂ OTHP	oil	CHCl ₃				3	
SeCH ₃	SCH ₂ CH ₂ OTHP						5	

SeCH ₃	SCH ₂ CH ₂ OH	5
SeCH ₃	SCH ₂ CH ₂ OTs	5
TMS ^{e)}	Cl	4
TMS ^{e)}	Br	4
TMS ^{e)}	I	4

^aSolvent for ¹HNMR. ^bSolvent for UV. ^cV vs. Ag /AgCl. ^dSEM = CH₂O(CH₂)₂Si(CH₃)₃. ^eTMS = Si(CH₃)₃.

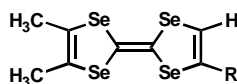
- (1) J. E. Rice, P. Wojciechowski, and Y. Okamoto, *Heterocycles*, **18**, 191 (1982).
- (2) M. Sallé, A. Gorgues, J. M. Fabre, K. Bechgaard, M. Jubault, and F. Texier, *J. Chem. Soc., Chem. Commun.*, 1520 (1989).
- (3) T. Jigami, K. Takimiya, and T. Otsubo, *J. Org. Chem.*, **63**, 8865 (1998).
- (4) Y. Kataoka, A. Morikami, K. Takimiya, Y. Aso, and T. Otsubo, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 4 C5 05 (1999).
- (5) T. Jigami, M. Kawshima, K. Takimiya, Y. Aso, T. Otsubo, *Synth. Met.*, **102**, 1619 (1999).
- (6) E. Fanghänel, and H. Poleschner, *Z. Chem.*, **19**, 192 (1979).
- (7) J. S. Zambounis, and C. W. Mayer, *Tetrahedron. Lett.*, **32**, 2741 (1991).
- (8) I. Johannsen, and H. Eggert, *J. Am. Chem. Soc.*, **106**, 1240 (1984).



R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
C(O)CH ₃	147-149	CS ₂ -cyclohexane				1
C(O)C ₃ H ₇	115-118	CS ₂ -hexane				1
C(O)C ₁₃ H ₂₇	wax					1
C(O)C ₁₅ H ₃₁	83-85	MeOH-CH ₂ Cl ₂				1
S-SEM ^{b)}						2
Se-SEM ^{b)}						2

^aSolvent for recrystallization (1:1, v/v). ^bSEM = CH₂O(CH₂)₂Si(CH₃)₃

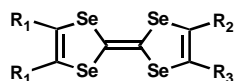
- (1) G. Cooke, M. R. Bryce, M. C. Petty, D. J. Ando, and M. B. Hursthouse, *Synthesis*, 465 (1993).
- (2) J. S. Zambounis, and C. W. Mayer, *Tetrahedron. Lett.*, **32**, 2741 (1991)



R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
CH ₃						2
CHO	199	CHCl ₃	0.65	0.96	CH ₃ CN 0.1M TBAP	1, 3
CH ₂ OH	203	CHCl ₃	0.45	0.72	CH ₃ CN 0.1M TBAP	1, 3
CH(OCH ₂ CH ₃) ₂	41	CHCl ₃	0.47	0.74	CH ₃ CN 0.1M TBAP	1, 3

^aSolvent for ¹HNMR.

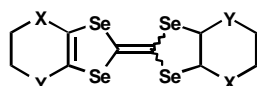
- (1) J. M. Fabre, S. Chakroune, L. Giral, A. Gorgues, and M. Sallé, *Synth. Met.*, **55-57**, 2073 (1993).
- (2) I. Johannsen, K. Bechgaard, C. S. Jacobsen, G. Rindorf, N. Thorup, K. Mortensen, and D. Mally, *Mol. Cryst. Liq. Cryst.*, **119**, 277 (1985).
- (3) J. M. Fabre, S. Chakroune, A. Gorgues, and L. Ouahab, *Synth. Met.*, **55-57**, 1978 (1993).



R ¹	R ²	R ³	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
S-SEM ^{a)}	S-SEM ^{a)}	H						1
Se-SEM ^{a)}	Se-SEM ^{a)}	H						1

^aSEM = CH₂O(CH₂)₂Si(CH₃)₃

(1) J. S. Zambounis, and C. W. Mayer, *Tetrahedron. Lett.*, **32**, 2741 (1991)



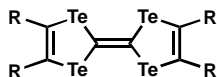
X	Y	mp/°C	solubility	E ₁	E ₂	CV (vs. SCE)	reference	
Se	S			0.67	0.95	CH ₃ CN	0.1M TBAHP ^{a)}	1, 3
Se	CH ₂							2
S	CH ₂							2

^a V vs. Ag/ AgCl

(1) M. Kawashima, T. Jigami, K. Takimiya, Y. Aso, and T. Otsubo, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan I*, 1 E7 26 (1999).

(2) M. Kodani, T. Jigami, K. Takimiya, Y. Aso, and T. Otsubo, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan I*, 1 E7 27 (1999).

(3) T. Jigami, M. Kawshima, K. Takimiya, Y. Aso, T. Otsubo, *Synth. Met.*, **102**, 1619 (1999).



R	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference	
H		CS ₂ -benzene	0.59	0.84	CH ₂ Cl ₂	0.2M TBAT	1, 2
-(CH ₂) ₃ -		CS ₂ , TCE ^{c)}	0.40	0.69	PhCN	TBAA	3
		<i>n</i> BuCN ^{d)}	0.12	0.34	<i>n</i> BuCN	0.1M TBAT ^{b)}	5, 6
-(CH=CH) ₂ -		TCE ^{b)}	0.71	1.05	CH ₂ Cl ₂	0.2M TBAT	4
		<i>n</i> BuCN ^{d)}	0.29	0.72	<i>n</i> BuCN	0.1M TBAT ^{b)}	5, 6

^aSolvent for ¹HNMR. ^bSolvent for recrystallization. ^cSolvent for UV. ^dSolvent for CV.

(1) R. D. McCullough, G. B. Kok, K. A. Lerstrup, and D. O. Cowan, *J. Am. Chem. Soc.*, **109**, 4115 (1987).

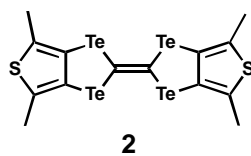
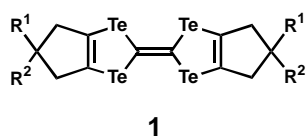
(2) R. D. McCullough, M. D. Mays, A. B. Bailey, and D. O. Cowan, *Synth. Met.*, **27**, B487 (1988).

(3) F. Wudl, and E. Aharon-Shalom, *J. Am. Chem. Soc.*, **104**, 1154 (1982).

(4) K. Lerstrup, D. Talham, A. Bloch, T. Poehler, D. Cowan, *J. Chem. Soc., Chem. Commun.*, 336 (1982).

(5) A. B. Bailey, R. D. McCullough, M. D. Mays, and D. O. Cowan, *Synth. Met.*, **27**, B425 (1988).

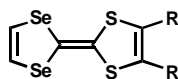
(6) K. Lerstrup, A. Bailey, R. McClough, M. Mays, D. Cowan, and T. Kistenmacher, *Synth. Met.*, **19**, 647 (1987).





	R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
1	CH ₃	H		<i>n</i> BuCN	0.08	0.34	<i>n</i> BuCN 0.1M TBAT ^{b)}	1, 2
	CH ₃	CH ₃		<i>n</i> BuCN	0.10	0.31	<i>n</i> BuCN 0.1M TBAT ^{b)}	1, 2
		-(CH ₂) ₂ -		<i>n</i> BuCN	0.11	0.34	<i>n</i> BuCN 0.1M TBAT ^{b)}	1, 2
2			295-298 (dec.)	TCE ^{b)}	0.78	1.20	CH ₂ Cl ₂ TBAT	3
				<i>n</i> BuCN	0.40	0.80	<i>n</i> BuCN 0.1M TBAT ^{b)}	2

^{a)}Solvent for CV. ^{b)}Solvent for recrystallization.

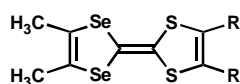
- (1) A. Bailey, R. McCullough, M. Mays, and D. Cowan, *Synth. Met.*, **27**, B425 (1988).
 (2) K. Lerstrup, A. Bailey, R. McClough, M. Mays, D. Cowan, and T. Kistenmacher, *Synth. Met.*, **19**, 647 (1987).
 (3) K. Lerstrup, D. O. Cowan, and T. J. Kistenmacher, *J. Am. Chem. Soc.*, **106**, 8303 (1984).



R (2R)	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
SCH ₃						1
-O(CH ₂) ₂ O-	90	CH ₃ CN				2
-SCH ₂ S-	158					1
-S(CH ₂) ₂ S-	207					1
-Se(CH ₂) ₂ Se-	210	CH ₃ CN				2
-SCH=CHS-						1
-S(CH ₂) ₃ S-						1
						1
						1

^{a)}Solvent for UV.

- (1) G. C. Papavassiliou, G. A. Mousdis, S. Y. Yiannopoulos, V. C. Kakoussis, and J. S. Zambounis, *Synth. Met.*, **27**, B373 (1988).
 (2) G. C. Papavassiliou, V. C. Kakoussis, D. J. Lagouvardos, and G. A. Mousdis, *Mol. Cryst. Liq. Cryst.*, **181**, 171 (1990).

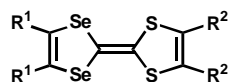


R	mp/°C	solubility	E ₁	E ₂	CV (vs. SCE)	reference
CH ₃						1, 2
-(CH ₂) ₄ -						2
-SCH ₂ S-	176-177	CH ₃ CN ^{c)}				3
-S(CH ₂) ₂ S-	198	CH ₃ CN ^{c)}	0.52	0.78	CH ₃ CN 0.1M TBAP	4

-S(CH ₂) ₃ S-	232	CH ₃ CN ^c	0.48	0.75	CH ₃ CN	0.1M TBAP	4
-SCH=CHS-	208 (dec.)	CHCl ₃ -CS ₂	0.59	0.91	CH ₃ CN	0.1M TBAP	5
-O(CH ₂) ₂ O-	240	CHCl ₃	0.42	0.7	CH ₃ CN	0.1M TBAP	6
SCH ₂ O(CH ₂) ₂ Si(CH ₃) ₃							3
SCH ₂ CH ₂ CN	124-125	CH ₂ Cl ₂	0.59	0.96	CH ₂ Cl ₂	0.1M TBAHP	10
SeCH ₂ CH ₂ CN	124-125	CHCl ₃ ^{a)}	d)		CH ₂ Cl ₂	0.1M TBAHP	7, 9
-Se(CH ₂) ₂ Se-	210 (dec.)	CH ₂ Cl ₂ -hexane ^{b)}	d)		CH ₂ Cl ₂	0.1M TBAHP	7, 9
I							8

^aSolvent for ¹HNMR. ^bSolvent for recrystallization. ^cSolvent for UV. ^d0.44V < E₁ < 0.59V and 0.78V < E₂ < 0.92V

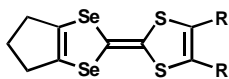
- (1) P. Auban, D. Jérôme, K. A. Lerst r up, I. Johannsen, M. Jørgensen, and K. Bechgaard, *J. Phys. France*., **50**, 2727 (1989).
- (2) J. M. Fabre, J. Amouroux, L. Giral, and D. Chasseau, *Synth. Met.*, **41-43**, 2049 (1991).
- (3) J. S. Zambounis, and C. W. Mayer, *Tetrahedron Lett.*, **32**, 2737 (1991).
- (4) K. Kikuchi, T. Namiki, I. Ikemoto, and K. Kobayashi, *J. Chem. Soc., Chem. Commun.*, 1472 (1986).
- (5) J. Yamada, S. Satoki, H. Anzai, K. Hagiya, M. Tamura, Y. Nishino, K. Kajita, E. Watanabe, M. Konno, T. Sato, H. Nishikawa, K. Kikuchi, *Chem. Commun.*, 1955 (1996).
- (6) J. M. Fabre, D. Serhani, K. Saoud, S. Chakroune, and M. Hoch, *Synth. Met.*, **60**, 295 (1993).
- (7) L. Binet, J. M. Fabre, and J. Becher, *Synthesis*, 26 (1997).
- (8) T. Maruyama, T. Imakubo, and K. Kobayashi, *Abstract of 72th Annual Meeting of the Chemical Society of Japan II*, 4H4 (1997).
- (9) J. Legros, F. Dahan, L. Binet, J. Fabre, *Synth. Met.*, **102**, 1632 (1999).
- (10) L. Binet, J. M. Fabre, C. Montginoul, K.B. Simonsen and J. Becher, *J. Chem. Soc., Perkin Trans. 1*, 783 (1996).



R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
CHO	H	203	CHCl ₃ ^{a)}				1
CHO	CH(OC ₂ H ₅) ₂	149	CHCl ₃ ^{a)}				1
CHO	-O(CH ₂) ₂ O-	149	CHCl ₃ ^{a)}				1
CH ₂ OH	H	172	CHCl ₃ ^{a)}				1
CH ₂ OH	-O(CH ₂) ₂ O-	150	CHCl ₃ ^{a)}				1
CH ₂ OH	CH(OC ₂ H ₅) ₂	150	CHCl ₃ ^{a)}				1
CO ₂ Me	-O(CH ₂) ₂ O-						2
CH(OC ₂ H ₅) ₂	H		CHCl ₃ ^{a)}				1
CH(OC ₂ H ₅) ₂	-O(CH ₂) ₂ O-		CHCl ₃ ^{a)}				1
CH(OC ₂ H ₅) ₂	CH(OC ₂ H ₅) ₂		CHCl ₃ ^{a)}				1
-CH ₂ SCH ₂ -	-S(CH ₂) ₂ S-						3
-Se(CH ₂) ₂ Se-	H	210	CH ₃ CN ^{b)}				2
-Se(CH ₂) ₂ Se-	CO ₂ Me						2
-Se(CH ₂) ₂ Se-	-O(CH ₂) ₂ O-	183	CH ₃ CN ^{b)}				4

^aSolvent for ¹HNMR. ^bSolvent for UV.

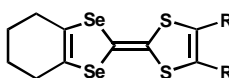
- (1) J. M. Fabre, S. Chakroune, L. Giral, A. Gorgues, and M. Sallé, *Synth. Met.*, **55-57**, 2073 (1993).
- (2) G. C. Papavassiliou, V. C. Kakoussis, D. J. Lagouvardos, and G. A. Mousdis, *Mol. Cryst. Liq. Cryst.*, **181**, 171 (1990).
- (3) M. Iso, Y. Okano, J. Yamaura, and R. Kato, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan I*, 1 E7 15 (1999).
- (4) G. C. Papavassiliou, *Synth. Met.*, **41-43**, 2535 (1991).



R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
-S(CH ₂) ₂ S-	214	CH ₃ CN ^{b)}	0.48	0.73	CH ₃ CN	0.1M TBAP	1
-SCH=CHS-	222 (dec.)	CHCl ₃ -CS ₂	0.6	0.91	CH ₃ CN	0.1M TBAP	2
-S(CH ₂) ₃ S-	234	CH ₃ CN ^{b)}	0.44	0.74	CH ₃ CN	0.1M TBAP	1

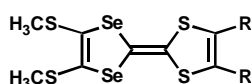
^{a)}Solvent for ¹HNMR. ^{b)}Solvent for UV.

- (1) K. Kikuchi, T. Namiki, I. Ikemoto, and K. Kobayashi, *J. Chem. Soc., Chem. Commun.*, 1472 (1986).
 (2) J. Yamada, S. Tatoki, H. Anzai, K. Hagiya, M. Tamura, Y. Nishino, K. Kajita, E. Watanabe, M. Konno, T. Sato, H. Nishikawa, K. Kikuchi, *Chem. Commun.*, 1955 (1996).



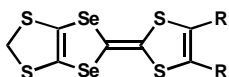
R	mp/°C	solubility	E_1	E_2	CV (vs. SCE)		reference
CH ₃							1
-(CH ₂) ₄ -							1
-S(CH ₂) ₂ S-							2, 4
-O(CH ₂) ₂ O-							2
-Se(CH ₂) ₂ Se-							3

- (1) J. M. Fabre, J. Amouroux, L. Giral, and D. Chasseau, *Synth. Met.*, **41-43**, 2049 (1991).
 (2) H. Isomitsu, K. Kamoshida, H. Sanaga, T. Kondoh, and G. Saito, *Abstract of 74th Annual Meeting of the Chemical Society of Japan I*, 4J314 (1998).
 (3) M. Iso, Y. Okano, J. Yamaura, and R. Kato, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan I*, 1 E7 15 (1999).
 (4) Y. Okano, M. Iso, Y. Kawashima, J. Yamaura, and R. Kato, *Synth. Met.*, **102**, 1703 (1999).



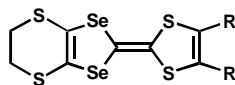
R	mp/°C	solubility	E_1	E_2	CV (vs. SCE)		reference
H							1

- (1) G. C. Papavassiliou, G. A. Mousdis, S. Y. Yiannopoulos, V. C. Kakoussis, and J. S. Zambounis, *Synth. Met.*, **27**, B373 (1988).



R	mp/°C	solubility	E_1	E_2	CV (vs. SCE)		reference
H							1

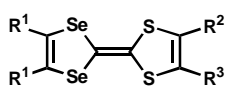
(1) G. C. Papavassiliou, G. A. Mousdis, S. Y. Yiannopoulos, V. C. Kakoussis, and J. S. Zambounis, *Synth. Met.*, **27**, B373 (1988).



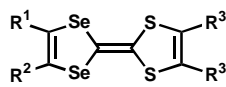
R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference	
H						1	
CH ₃						2	
-(CH ₂) ₄ -						7	
-O(CH ₂) ₂ O-	195 (dec.)	CHCl ₃	0.13	0.44	PhCN	0.1M TBAT ^{b)}	3
	186	CH ₃ CN ^{c)}					8
-SCH ₂ S-		CS ₂	0.18	0.41	PhCN	0.1M TBAP ^{b)}	4
-S(CH ₂) ₂ S-		PhCN ^{b)}	0.30	0.55	PhCN	0.1M TBAT ^{b)}	1, 3
-Se(CH ₂) ₂ Se-		CS ₂ ^{c)}					6
Se(CH ₂) ₂ CN		CS ₂ -CH ₂ Cl ₂ ^{c)}					6
-SCH ₂ OCH ₂ S-							1
-SCH=CHS-	231 (dec.)	CHCl ₃ -CS ₂					5

^{a)}Solvent for ¹HNMR. ^{b)}Solvent for CV. ^{c)}Solvent for UV.

- (1) A. Kobayashi, R. Kato, T. Naito, and H. Kobayashi, *Synth. Met.*, **55-57**, 2078 (1993).
- (2) K. Yoshino, T. Yamazaki, H. Saito, K. Saito, K. Kikuchi, and I. Ikemoto, *Abstracts of Symposium on Molecular Structure*, 2C12 (1993).
- (3) T. Imakubo, Y. Okano, H. Sawa, and R. Kato, *J. Chem. Soc., Chem. Commun.*, 2493 (1995).
- (4) S. Aonuma, Y. Okano, H. Sawa, R. Kato, H. Kobayashi, *J. Chem. Soc. Chem. Commun.*, 1193 (1192).
- (5) J. Yamada, S. Satoki, H. Anzai, K. Hagiya, M. Tamura, Y. Nishino, K. Kajita, E. Watanabe, M. Konno, T. Sato, H. Nishikawa, K. Kikuchi, *Chem. Commun.*, 1955 (1996).
- (6) Y. Okano, J. Yamaura, and R. Kato, *Abstracts of 76 th Annual Meeting of Chemical Society of Japan I*, 2PA014 (1999).
- (7) N. Sakurai, H. Mori, S. Tanaka, H. Moriyama, *Synth. Met.*, **102**, 1682 (1999)
- (8) G. C. Papavassiliou, *Synth. Met.*, **41-43**, 2535 (1991).



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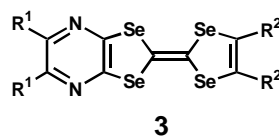
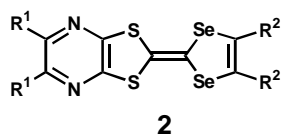
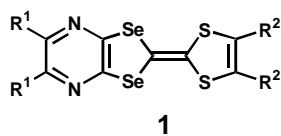


2

	R1	R2	R3	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1	CH ₃	SCH ₂ Br	S-SEM						1
	-Se(CH ₂) ₂ Se	H	COOCH ₃						2
2	H	COOCH ₃	-O(CH ₂) ₂ O-						2

^{a)}SEM = CH₂O(CH₂)₂Si(CH₃)₃

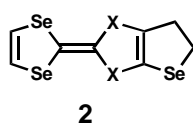
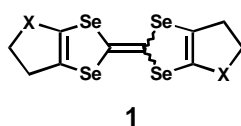
- (1) J. S. Zambounis, and C. W. Mayer, *Tetrahedron Lett.*, **32**, 2737 (1991).
- (2) G. C. Papavassiliou, V. C. Kakoussis, D. J. Lagouvardos, and G. A. Mousdis, *Mol. Cryst. Liq. Cryst.*, **181**, 171 (1990).



	R ¹	R ²	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
1	H	H	174	CH ₃ CN				1
	H	CH ₃	180	CH ₃ CN				1
	H	CO ₂ Me						1
	H	-O(CH ₂) ₂ O-	210	CH ₃ CN				2
	H	-SCH ₂ S-	218	CH ₃ CN	0.69	0.96	CH ₃ CN 0.1M TEAP	1, 3
	H	-S(CH ₂) ₂ S-	229	CH ₃ CN	0.74	1.03	CH ₃ CN 0.1M TEAP	1, 3
	H	I	>250	CHCl ₃ ^{b)}				4
	CH ₃	-SCH ₂ S-	218	CH ₃ CN	0.66	0.92	CH ₃ CN 0.1M TEAP	1, 3
	CH ₃	-S(CH ₂) ₂ S-	238	CH ₃ CN	0.59	0.99	CH ₃ CN 0.1M TEAP	1, 3
2	H	CH ₃	282	CH ₃ CN	0.69	1.02	CH ₃ CN 0.1M TEAP	1, 3
	CH ₃	CH ₃	302	CH ₃ CN	0.63	0.93	CH ₃ CN 0.1M TEAP	1, 3
	H	-(CH ₂) ₃ -	220	CH ₃ CN				1
	H	-S(CH ₂) ₂ S-	229	CH ₃ CN	0.85	1.18	PhCN	5
3	H	CH ₃	258	CH ₃ CN				1

^aSolvent for UV. ^bSolvent for ¹HNMR. ^cSolvent for chromatography.

- (1) G. C. Papavassiliou, V. Gionis, S. Y. Yiannopoulos, J. S. Zambounis, G. A. Mousdis, K. Kobayashi, and K. Umemoto, *Mol. Cryst. Liq. Cryst.*, **156**, 277 (1988).
- (2) G. C. Papavassiliou, V. C. Kakoussis, D. J. Lagouvardos, and G. A. Mousdis, *Mol. Cryst. Liq. Cryst.*, **181**, 171 (1990).
- (3) G. C. Papavassiliou, S. Y. Yiannopoulos, J. S. Zambounis, K. Kobayashi, and K. Umemoto, *Chem. Lett.*, 1279 (1987).
- (4) T. Imakubo, T. Maruyama, H. Sawa, and K. Kobayashi, *Chem. Commun.*, 2021 (1998).
- (5) E. Ojima, H. Fujiwara, and H. Kobayashi, *Abstracts of Symposium on Molecular Structure*, 1P64 (1998).

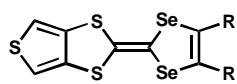


	X	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. Ag / AgCl)	reference
1	Se	205-207	CHCl ₃ -CS ₂	0.47	0.74	PhCN 0.1M TBAP	1
2	S			0.39	0.78	PhCN TBAP	2
	Se			0.47	0.78	PhCN TBAP	2

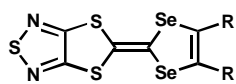
^aSolvent for ¹HNMR.

^aSolvent for ¹HNMR. ^bSolvent for CV.

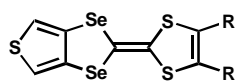
- (1) T. Jigami, K. Takimiya, and T. Otsubo, *J. Org. Chem.*, **63**, 8873 (1998).
- (2) S. Murakami, T. Jigami, K. Takimiya, Y. Aso, and T. Otsubo, *Abstracts of Symposium on Molecular Structure*, 1P63 (1998).



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2



3

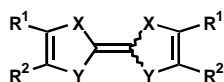
	R	mp/°C	solubility ^{a)}	E_1	E_2	E_3	CV (vs. SCE)	reference
1	CH ₃		CH ₃ CN ^{b)}	0.79	1.16	1.61	CH ₃ CN 0.1M TBAP	1
	-(CH ₂) ₃ -		CH ₃ CN ^{b)}	0.54	1.01		CH ₃ CN 0.1M TBAP	1
	-S(CH ₂) ₂ S-		CH ₃ CN ^{b)}	0.67	1.08	1.48	CH ₃ CN 0.1M TBAP	1
2	CH ₃	224-225	EtOH-CHCl ₃	0.86	1.17	1.46	CH ₃ CN 0.1M TBAP	1, 2
	-(CH ₂) ₃ -	220 (dec.)	EtOH-CHCl ₃	0.84	1.17	1.37	CH ₃ CN 0.1M TBAP	1, 2
	-S(CH ₂) ₂ S-							3
3	CH ₃		CH ₃ CN ^{b)}	0.50	0.95 ^{c)}	1.69 ^{c)}	CH ₃ CN 0.1M TBAP	1
	-S(CH ₂) ₂ S-		CH ₃ CN ^{b)}	0.65	1.03 ^{c)}	1.46 ^{c)}	CH ₃ CN 0.1M TBAP	1

^{a)}Solvent for recrystallization. ^{b)}Solvent for CV. ^{c)}Irreversible oxidation wave.

(1) J. Yamada, *Recent Res. Devel. In Organic Chem.*, **2**, 525 (1998).

(2) J. Yamada, S. Satoki, S. Mishima, N. Akashi, K. Takahashi, N. Masuda, Y. Nishimoto, S. Takasaki, and H. Anzai, *J. Org. Chem.*, **61**, 3987 (1996).

(3) T. Naito, K. Kawano, H. Kobayashi, and A. Kobayashi, *Abstracts of Symposium on Molecular Structure*, 4E08 (1994).



R ¹	R ²	X	Y	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
H	H	S	Se	118	cyclohexaen ^{b)}	0.4	0.72	CH ₃ CN 0.1M TBAP	1, 2, 3
H	CO ₂ H	S	Se						13
H	CO ₂ Me	S	Se	254-255	benzene-MeOH				13
CO ₂ H	CO ₂ H	S	Se	>280					2
CO ₂ Me	CO ₂ Me	S	Se	138					2
CONH ₂	CONH ₂	S	Se						13
CH ₃	H	S	Se	123-125	hexane ^{b)}				4
Ph	H	S	Se	202-208	CH ₃ CN				12
-(CH ₂) ₃ -		S	Se	244 (dec.)	CH ₂ Cl ₂ ^{b)}				5
		S	Se	160-163	hexane	0.39	0.70	CH ₃ CN 0.1M TEAP	10
-(CH ₂) ₄ -		S	Se			0.28	0.63	CH ₃ CN	11
-(CH=CH) ₂ -		S	Se	247-248	CH ₃ CN ^{b)}				5
-O(CH ₂) ₂ O-		S	Se	29.9-30.7	CHCl ₃	0.01	0.3	PhCN 0.01M TBAT ^{d)}	6
CH ₃	CH ₃	S	Se		CHCl ₃	0.33	0.68	CH ₃ CN 0.1M TBAT	7
-S(CH ₂) ₂ S-	-S(CH ₂) ₂ S-	S	Se						8
H	H	Se	Te	139-140	CHCl ₃	0.43	0.73		^{c)} 9
CH ₃	H	Se	Te	39.0-39.7	CHCl ₃	0.41	0.71		^{c)} 9

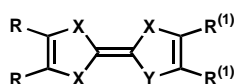
^{a)}Solvent for ¹HNMR. ^{b)}Solvent for UV. ^{c)}V vs. Ag / AgCl. ^{d)}V vs. Ag / AgNO₃.


(1) E. M. Engler, F. B. Kaufman, D. C. Green, C. E. Klots, and R. N. Compton, *J. Am. Chem. Soc.*, **97**, 2921 (1975).

(2) M. V. Lakshmikantham, M. P. Cava, and A. F. Garito, *J. Chem. Soc., Chem. Commun.*, 383 (1975).

(3) E. M. Engler, and V. V. Patel, *J. Chem. Soc., Chem. Commun.*, 671 (1975).

- (4) E. M. Engler, and V. V. Patel, *Tetrahedron Lett.*, 423 (1976).
 (5) H. K. Spencer, M. V. Lakshmikantham, M. P. Cava, and A. F. Garto, *J. Chem. Soc., Chem. Commun.*, 867 (1975).
 (6) T. Imakubo, and K. Kobayashi, *J. Mater. Chem.*, **8**, 1945 (1998).
 (7) F. Wudl, W. M. Walsh Jr., J. J. Hauser, F. J. Disalvo, D. Nalewajek, L. W. Rupp. Jr., J. V. Waszczak, and R. J. Felder, *J. Chem. Phys.*, **79**, 1004 (1983).
 (8) G. C. Papavassiliou, D. J. Lagouvardos, A. Terzis, A. Hountas, B. Hilti, J. S. Zambounis, C. W. Mayer, J. Pfeiffer, W. Hofherr, P. Delhaes, and J. Amiell, *Synth. Met.*, **55-57**, 2174 (1993).
 (9) K. Takimiya, A. Morikami, Y. Aso, and T. Otsubo, *Chem. Commun.*, 1925 (1997).
 (10) E. M. Engler, V. V. Patel, J. R. Andersen, R. R. Schumaker, and A. A. Fukushima, *J. Am. Chem. Soc.*, **100**, 3769 (1978).
 (11) R. C. Wheland, and J. L. Gillson, *J. Am. Chem. Soc.*, **98**, 3916 (1976).
 (12) E. Fanghänel, and H. Poleschner, *Z. Chem.*, **19**, 192 (1979).
 (13) J. E. Rice, P. Wojciechowaki, and Y. Okamoto, *Heterocycles*, **18**, 191 (1982).

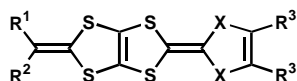


X	Y	R	(R ¹)	mp/°C	solubility ^{a)}	E ₁	E ₂	CV (vs. SCE)	reference
S	Se	-S(CH ₂) ₂ S-							1
S	Se	-S(CH ₂) ₂ S-	(H)						1
S	Se	-O(CH ₂) ₂ O-	(-S(CH ₂) ₂ S-)	196	CS ₂ ^{d)}				5
S	Se	S-SEM ^{e)}	(-S(CH ₂) ₂ S-)	196	CS ₂ ^{d)}				1
Se	S	CO ₂ Me		140-141	benzene-MeOH				2
Se	S	CF ₃		103.5-104	hexane				2
Se	S	CH ₃ ^{c)}		253-254 (dec.)	iso-octane				2
Se	S		(-S(CH ₂) ₂ S-)	233	CH ₂ Cl ₂ ^{d)}				5
S	O	-(CH=CH) ₂ -		154.7-156.9	CHCl ₃ ^{b)}	0.72	1.12	CH ₂ Cl ₂ 0.2M TBAT	3
Se	Te								4

^aSolvent for recrystallization. ^bSolvent for ¹HNMR. ^cMixture with TMTSF. ^dSolvent for chromatography.

^eSEM=CH₂O(CH₂)₂SiMe₃

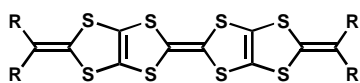
- (1) G. C. Papavassiliou, D. J. Lagouvardos, A. Terzis, A. Hountas, B. Hilti, J. S. Zambounis, C. W. Mayer, J. Pfeiffer, W. Hofherr, P. Delhaes, and J. Amiell, *Synth. Met.*, **55-57**, 2174 (1993).
 (2) E. M. Engler, and V. V. Patel, *J. Chem. Soc., Chem. Commun.*, 835 (1977).
 (3) S. T. D'Arcangelis, and D. O. Cawan, *Tetrahedron Lett.*, **37**, 2931 (1996).
 (4) A. Morikami, K. Takimiya, Y. Aso, and T. Otsubo, *Abstracts of 76th Annual Meeting of Chemical Society of Japan I*, 2PA016 (1999).
 (5) D. J. Lagouvardos, and G. C. Papavassiliou, *Z. Naturforsch. B*, **47**, 898 (1992).



R ¹	R ²	R ³	X	mp/°C	solubility ^{a)}	E ₁	E ₂	E ₃	CV (vs. SCE)	reference
CH ₃	CH ₃	H	S	167 (dec.)	CHCl ₃ -CS ₂	0.45	0.76	1.41	PhCN 0.1M TBAP	1
CH ₃	CH ₃	CO ₂ Me	S	212 (dec.)	CHCl ₃ -CS ₂	0.62	0.91	1.51	PhCN 0.1M TBAP	1
CH ₃	CH ₃	CH ₃	S			0.43	0.75	1.37	PhCN 0.1M TBAP	3
CH ₃	CH ₃	SCH ₃	S	164-166 (dec.)	CHCl ₃ -CS ₂	0.50	0.75	1.39	PhCN 0.1M TBAP	1
CH ₃	CH ₃	-SCH ₂ S-	S	195 (dec.)	CHCl ₃ -CS ₂	0.51	0.83		PhCN 0.1M TBAP	1
CH ₃	CH ₃	-S(CH ₂) ₂ S-	S	201 (dec.)	CHCl ₃ -CS ₂	0.51	0.79	1.39	PhCN 0.1M TBAP	1
CH ₃	CH ₃	-S(CH ₂) ₃ S-	S	200-202 (dec.)	CHCl ₃ -CS ₂	0.50	0.78	1.45	PhCN 0.1M TBAP	1
CH ₃	CH ₃	-(CH=CH ₂) ₂	S	214 (dec.)	CHCl ₃ -CS ₂					4
CH ₃	CH ₃		S		PhCN-CS ₂ ^{c)}	0.68	0.91	1.35	^{d)} 0.1M TBAP	7
CH ₃	C ₂ H ₅	-S(CH ₂) ₂ S-	S							2
C ₂ H ₅	C ₂ H ₅	-S(CH ₂) ₂ S-	S							2
	-(CH ₂) ₄ -	H	S	161-162 (dec.)	CHCl ₃ -CS ₂	0.43	0.74	1.43	PhCN 0.1M TBAP	5
	-(CH ₂) ₄ -	CO ₂ Me	S	214.5 (dec.)	CHCl ₃ -CS ₂	0.60	0.89	1.47	PhCN 0.1M TBAP	5
	-(CH ₂) ₄ -	SCH ₃	S	172-173 (dec.)	acetone-CS ₂	0.50	0.75	1.37	PhCN 0.1M TBAP	5
	-(CH ₂) ₄ -	-SCH ₂ S-	S	215-215.5 (dec.)	CHCl ₃ -CS ₂	0.51	0.74	1.37	PhCN 0.1M TBAP	5
	-(CH ₂) ₄ -	-S(CH ₂) ₂ S-	S	213-214 (dec.)	acetone-CS ₂	0.51	0.77	1.38	PhCN 0.1M TBAP	5
	-(CH ₂) ₄ -	-(CH=CH ₂) ₂	S	210 (dec.)	CHCl ₃ -CS ₂					4
	-(CH ₂) ₄ -		S		PhCN-CS ₂ ^{c)}	0.67	0.91	1.34	^{d)} 0.1M TBAP	7
CH ₃	CH ₃	CH ₃	Se		CS ₂	0.07	0.36	1.00	PhCN 0.1M TBAP ^{b)}	6
CH ₃	CH ₃	-S(CH ₂) ₂ S-	Se		CS ₂	0.17	0.41	0.95	PhCN 0.1M TBAP ^{b)}	6

^{a)}Solvent for ¹H-NMR. ^{b)}V vs. Ag / AgCl. ^{c)}Solvent for CV. ^{d)}PhCN-CS₂, 1:1

- (1) Y. Misaki, H. Nishikawa, H. Fujiwara, K. Kawakami, T. Yamabe, H. Yamochi, and G. Saito, *J. Chem. Soc., Chem. Commun.*, 1408 (1992).
- (2) H. Fujiwara, T. Miura, Y. Misaki, T. Yamabe, T. Mori, H. Mori, S. Tanaka, *Mol. Cryst. Liq. Cryst.*, **284**, 329 (1996).
- (3) Y. Misaki, M. Taniguchi, T. Miura, H. Fujiwara, T. Yamabe, T. Kawamoto, and T. Mori, *Adv. Mater.* **9**, 633 (1997).
- (4) J. Yamada, S. Satoki, S. Mishima, N. Akashi, K. Takahashi, N. Masuda, Y. Nishimoto, S. Takasaki, and H. Anzai *J. Org. Chem.*, **61**, 3987 (1996).
- (5) Y. Misaki, K. Kawakami, H. Nishikawa, H. Fujiwara, T. Yamabe, and M. Shiro, *Chem. Lett.* 445 (1993).
- (6) S. Aonuma, Y. Okano, H. Sawa, R. Kato, and H. Kobayashi, *J. Chem. Soc., Chem. Commun.*, 1193 (1992).
- (7) T. Yamashita, J. Yamada, and H. Anzai, *Abstracts of 72nd Annual Meeting of the Chemical Society of Japan.*, 4H440 (1996).

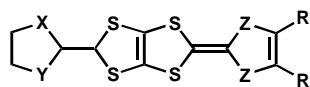


R (2R)	mp/°C	solubility ^{a)}	E ₁	E ₂	E ₃	CV (vs. SCE)	reference
CH ₃	222.5-223 (dec.)	acetone-CS ₂					1
C ₂ H ₅	195-196.5	CH ₂ Cl ₂ ^{b)}	0.52	0.73	1.27	PhCN 0.1M TBAP	1

C ₃ H ₇	167-168	CH ₂ Cl ₂ ^{b)}	0.51	0.73	1.31	PhCN	0.1M TBAP	1
-(CH ₂) ₄ -	200-200.5 (dec.)							1

^aSolvent for ¹H-NMR. ^bSolvent for UV.

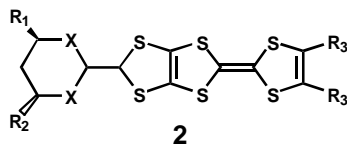
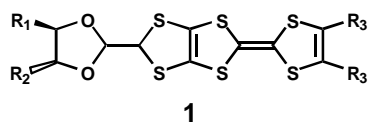
(1) Y. Misaki, H. Nishikawa, K. Kawakami, T. Uehara, and T. Yamabe, *Tetrahedron Lett.*, **33**, 4321 (1992).



X	Y	R	Z	mp/°C	solubility ^{a)}	E ₁	E ₂	E ₃	E ₄	CV (vs. SCE)	reference
O	O	H	S	113-114	CHCl ₃	0.53	0.92			PhCN 0.1M TBAP	1
O	O	-S(CH ₂) ₂ S-	S	175 (dec.)	CHCl ₃	0.57	0.84	1.58		PhCN 0.1M TBAP	1
O	O	CH ₃	Se	198 (dec.)	CHCl ₃	0.53	0.83	1.58		PhCN 0.1M TBAP	1
O	O	-SCH ₂ S-	S	180 (dec.)	CHCl ₃ -CS ₂	0.53	0.76	1.38	1.56	PhCN 0.1M TBAP	2
O	O	-SCH=CHS-	S			0.65	0.90	1.60	1.74 ^{b)}	PhCN 0.1M TBAP	3
O	O	COOMe	S								4
S	S	-S(CH ₂) ₂ S-	S	168 (dec.)	CHCl ₃ -CS ₂	0.55	0.83	1.63		PhCN 0.1M TBAP	2
S	S	-SCH ₂ S-	S	184 (dec.)	CHCl ₃ -CS ₂	0.55	0.77	1.57		PhCN 0.1M TBAP	2
S	S	-SCH=CHS-	S			0.65	0.88	1.70 ^{b)}		PhCN 0.1M TBAP	3
S	S	H	S	137 (dec.)	CHCl ₃ -CS ₂	0.48	0.80	1.67		PhCN 0.1M TBAP	2
S	S	COOMe	S								2
O	S	-S(CH ₂) ₂ S-	S	153 (dec.)	CHCl ₃ -CS ₂	0.55	0.83	1.64		PhCN 0.1M TBAP	2

^aSolvent for ¹H-NMR. ^b Irreversible wave.

- (1) J. Yamada, M. Hamasaki, O. Jinih, S. Tanaka, K. Hagiya, and H. Anzai, *Tetrahedron Lett.*, **38**, 3439 (1997).
 (2) J. Yamada, R. Oka, H. Anzai, H. Nishikawa, I. Ikemoto, and K. Kikuchi, *Tetrahedron Lett.*, **39**, 7709 (1998).
 (3) T. Ozasa, J. Yamada, S. Nkatsuji, H. Nishikawa, I. Ikemoto, and K. Kikuchi, *Abstracts of 70th Annual Meeting of the Chemical Society of Japan II*, 3 PA 153 (1999).
 (4) J. Yamada, R. Oka, H. Anzai, H. Nishikawa, I. Ikemoto, K. Kikuchi, *Synth. Met.*, **102**, 1701 (1999).

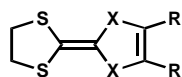


	X	R ₁	R ₂	R ₃	mp/°C	solubility	E ₁	E ₂	E ₃	E ₄	CV (vs. SCE)	reference
1		CH ₃	CH ₃	-S(CH ₂) ₂ S-								1
1		CH ₃	CH ₃	-SCH ₂ S-								1
1		CH ₃	H	-S(CH ₂) ₂ S-								1
2	O	H	H	-S(CH ₂) ₂ S-								2
	O	H	H	-SCH ₂ S-								2

S	H	H	-S(CH ₂) ₂ S-	2
S	H	H	-SCH ₂ S-	2
O	CH ₃	CH ₃	-S(CH ₂) ₂ S-	2

(1) R. Oka, T. Hnajiri, J. Yamada, S. Nakatsuji, H. Nishikawa, I. Ikemoto, and K. Kikuchi, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 4 C5 13 (1999).

(2) T. Mangetsu, J. Yamada, S. Nakatsuji, H. Nishikawa, I. Ikemoto, and K. Kikuchi, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 4 C5 14 (1999).



R	X	mp/°C	solubility ^{a)}	E_1	E_2	E_2	CV (vs. SCE)	reference
H	S	115	CHCl ₃	0.41	0.89		CH ₃ CN 0.1M TEAP	1, 2, 3
-SCH ₂ S-	S	129 (dec.)	CHCl ₃	0.60	1.00	1.14	CH ₃ CN 0.1M TBAP	4, 6, 7
-S(CH ₂) ₂ S-	S	223.5	CHCl ₃	0.63	1.02		CH ₃ CN 0.1M TBAP	4, 6, 7
-Se(CH ₂) ₂ Se	S			0.57	0.91		PhCN 0.1M TBAP	8
-SCH=CHS-	S	184	CHCl ₃ -EtOH ^{b)}	0.69	1.05		CH ₃ CN 0.1M TBAP	4, 6, 7
	S	105.5-106	CH ₂ Cl ₂ ^{b)}	0.75	1.17		CH ₃ CN 0.1M TBAP	4, 6, 7
-(CH=CH ₂) ₂	S	184-185	CHCl ₃					2
CH ₃	Se	155.5-156	CHCl ₃ -EtOH ^{b)}	0.56	0.97		CH ₃ CN 0.1M TBAP	4, 6, 7
-(CH ₂) ₃ -	Se	196(dec.)	CHCl ₃ -EtOH ^{b)}	0.56	0.98		CH ₃ CN 0.1M TBAP	4, 6, 7
-S(CH ₂) ₂ S-	Se	201 (dec.)	CHCl ₃	0.73			CH ₃ CN 0.1M TBAP	4, 7
	S		CHCl ₃	0.62	1.02		PhCN 0.1M TBAP	5

^aSolvent for ¹H-NMR. ^bSolvent for recrystalliation.

(1) D. L. Coffen, P. E. Garrett, *Tetrahedron Lett.*, 2043 (1969).

(2) T. Mori, and Inokuchi, *Chem. Lett.*, 1873 (1992).

(3) D. L. Coffen, J. Q. Chambers, D. R. Williams, P. E. Gerrett, and N. D. Canfield, *J. Amer. Chem. Soc.*, **93**, 2258 (1971).

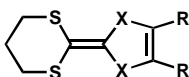
(4) J. Yamada, S. Takasaki, M. Kobayashi, H. Anzai, N. Tajima, M. Tamura, Y. Nishio, and K. Kajita, *Chem. Lett.*, 1069 (1995).

(5) J. Yamada, M. Hamasaki, O. Jinih, S. Tanaka, K. Hagiya, and H. Anzai, *Tetrahedron Lett.*, **38**, 3439 (1992).

(6) J. Yamada, Y. Amano, S. Takasaki, R. Nakanishi, K. Matsumoto, S. Satoki, and H. Anzai, *J. Amer. Chem. Soc.*, **117**, 1149 (1995).

(7) J. Yamada, S. Satoki, S. Mishima, N. Akashi, K. Takahashi, N. Masauda, Y. Nishimoto, S. Takasaki, and H. Anzai, *J. Org. Chem.*, **61**, 3987 (1996).

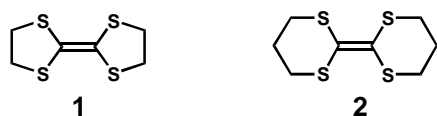
(8) T. Isaka, H. Nishikawa, I. Ikemoto, K. Kikuchi, J. Yamada, and H. Anzai, *Abstract of 74th Annual Meetings of the Chemical Society of Japan II*, 2D341 (1998).



R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
-SCH ₂ S-	180 (dec.)	CHCl ₃	0.67	1.06	PhCN	0.1M TBAP	1, 3
-S(CH ₂) ₂ S-	152-153	CHCl ₃	0.69	0.99	PhCN	0.1M TBAP	1, 3
-SCH=CHS-	148-149	CHCl ₃ -EtOH ^b					2, 3

^aSolvent for ¹H-NMR. ^bSolvent for recrystalliation.

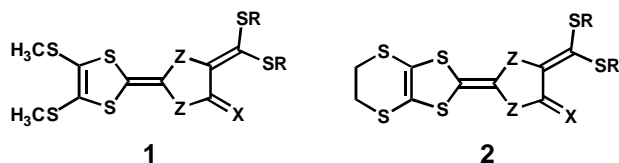
- (1) J. Yamada, N. Akashi, H. Anzai, M. Tamura, Y. Nishio, K. Kajita, *Mol. Cryst. Liq. Cryst.*, **296**, 53 (1997).
 (2) J. Yamada, Y. Amano, S. Takasaki, R. Nakanishi, K. Matsumoto, S. Satoki, and H. Anzai, *J. Amer. Chem. Soc.*, **117**, 1149 (1995).
 (3) J. Yamada, S. Satoki, S. Mishima, N. Akashi, K. Takahashi, N. Masauda, Y. Nishimoto, S. Takasaki, and H. Anzai *J. Org. Chem.*, **61**, 3987 (1996).



	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
1	200-202	CHCl ₃	0.68	1.12	CH ₃ CN	0.1M TEAP	1, 2
2			0.695	0.840	CH ₃ CN	0.1M TEAP	1, 2

^aSolvent for ¹H-NMR

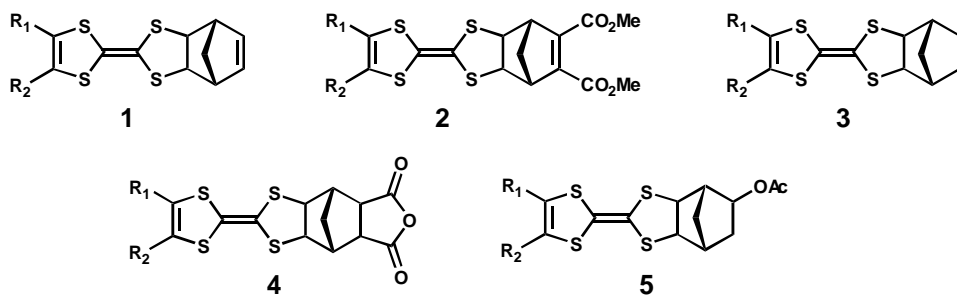
- (1) D. L. Coffen, P. E. Garrett, *Tetrahedron Lett.*, 2043 (1969).
 (2) D. L. Coffen, J. Q. Chambers, D. R. Williams, P. E. Gerrett, and N. D. Canfield, *J. Amer. Chem. Soc.*, **93**, 2258 (1971).



	X	R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. Ag/AgCl)		reference
1	O	-CH ₂ CH ₂ -		CS ₂ -MeOH	0.62	0.78	DMF	0.1M TEAP	1
1	O	-CH=CH-		CS ₂ -MeOH	0.62	0.85	DMF	0.1M TEAP	1
1	O			CS ₂ -MeOH	0.66	0.85	DMF	0.1M TEAP	1
1	S	-CH ₂ CH ₂ -		CS ₂ -MeOH	0.59	0.76	DMF	0.1M TEAP	1
1	S	-CH=CH-		CS ₂ -MeOH	0.61	0.77	DMF	0.1M TEAP	1
1	S			CS ₂ -MeOH	0.64	0.80	DMF	0.1M TEAP	1
2	S	-CH=CH-							2

^aSolvent for recrystalliation.

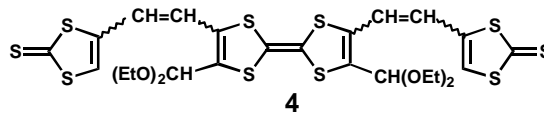
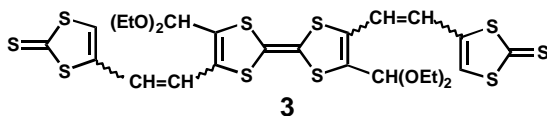
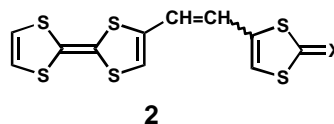
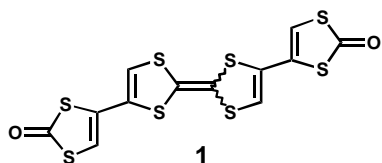
- (1) M. Iwamatsu, T. Kominami, K. Ueda, T. Sugimoto, H. Fujita, and T. Adachi, *Chem. Lett.*, 329 (1999).
 (2) M. Iwamatsu, T. Kominami, K. Ueda, T. Sugimoto, H. Fujita, T. Adachi, H. Yoshino, and K. Murata, *Abstracts of Symposium on Molecular Structure*, 1pA02 (1999).



	R1	R2	mp/°C	solubility	E_1	E_2	CV (vs. SCE)	reference
1	CO ₂ Me	CO ₂ Me	103-104					1
	CO ₂ Et	CO ₂ Et	73-75					1
	CO ₂ Me	H	137-138					1
	CO ₂ Et	H	123-126					1
	CO ₂ Me	Ph	90-93					1
2	CO ₂ Me	CO ₂ Me	146-147					1
3	CO ₂ Me	CO ₂ Me	110-111					2
	CO ₂ Et	CO ₂ Et	86-87					2
	CO ₂ Me	H	123-124					2
	CO ₂ Et	H	110-112					2
	CO ₂ Me	Ph	48-50					2
4	CO ₂ Me	CO ₂ Me	272-273					2
5	CO ₂ Me	CO ₂ Me	135-141					2
	CO ₂ Et	CO ₂ Et	oil					2

(1) R. A. Aitken, L. Hill, and N. J. Wilson, *Tetrahedron Lett.*, **40**, 1061 (1999).

(2) R. A. Aitken, L. Hill, and P. Lightfoot, *Tetrahedron Lett.*, **38**, 7927 (1997).

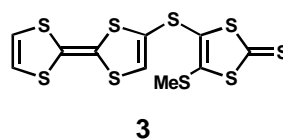
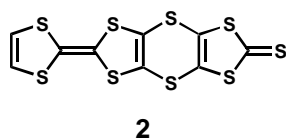
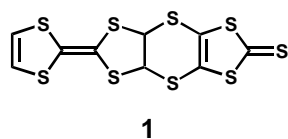


X	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
1	275-277	CHCl ₃	0.78	0.90	DMF	0.1M TEAP	1
2	O						2
	S <i>trans</i> 210 (dec.)	DMSO	0.67	0.96	THF	0.1M TBAP	2
3							2
4							2

^aSolvent for ¹HNMR.

(1) J. R. Andersen, V. V. Patel, and E. M. Engler, *Tetrahedron Lett.*, 239 (1978).

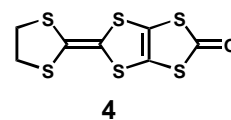
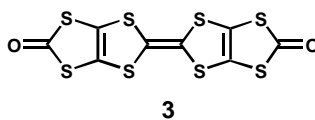
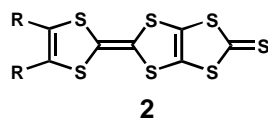
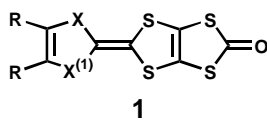
(2) T. Nozdryn, J. Cousseau, A. Gorues, M. Jubault, J. Orduna, S. Uriel, and J. Garín, *J. Chem. Soc. Perkin Trans. I*, 1711 (1993).



	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. Ag / AgCl)		reference
1	165 (dec.)	benzene	0.37	0.72	DMF	0.1M TBAP	1
2	231-232 (dec.)	toluene or PhCl	0.59	0.71	DMF	0.1M TBAP	1
3	oi.	CHCl ₃ ^{b)}	0.48	0.67	DMF	0.1M TBAP	1

^aSolvent for recrystallization. ^bSolvent for ¹HNMR.

(1) V. Y. Khodorkovskiy, J. Y. Becker, and J. Bernstein, *Synthesis*, 1071 (1992).

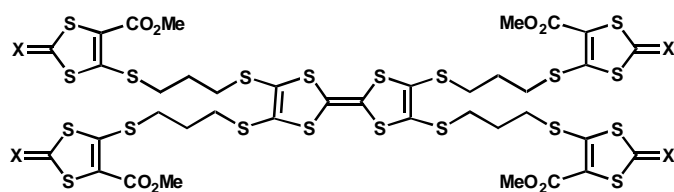


	R	X	(X ¹)	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1	H	S		152.0-152.8 (dec.)	CS ₂ -benzene				1, 6
	CH ₃	S							2
	CN	S		196 (dec.)	CH ₃ CN ^{b)}				4
	CF ₃	S		146-147	hexane ^{b)}				4

	CO ₂ Me	S	215-220 (dec.)	CHCl ₃ -hexane ^{c)}	5
	-(CH ₂) ₃ -	S	184-185 (dec.)	PhCl ^{b)}	8
	-(CH ₂) ₄ -	S			9
	-(CH=CH) ₂ -	S			10
	SCH ₃	S	178 (dec.)	CHCl ₃	3
		S	192-193	CS ₂ -CHCl ₃	6
	SEt	S	167-168 (dec.)	CHCl ₃	6, 7
	SC ₆ H ₁₃ ⁿ	S	132-133.5	CHCl ₃	6, 7
	-SCH ₂ S-	S			11
	-S(CH ₂) ₂ S-	S			11
	-S(CH ₂) ₃ S-	S			11
	-O(CH ₂) ₂ O-	S			12
	-Se(CH ₂) ₂ Se	S			13
	CH ₃	Se	222	CHCl ₃ -CS ₂ ^{b)}	16
	-(CH ₂) ₃ -	Se	198	CHCl ₃ -CS ₂ ^{b)}	16
	CO ₂ Me	S (Se)	204 (dec.)	nitrobenzene	17
2	H				14
	CH ₃				15
	SCH ₃				15
	-O(CH ₂) ₂ O-				15
3			>360		3
4			212 (dec.)	CS ₂ ^{b)}	16

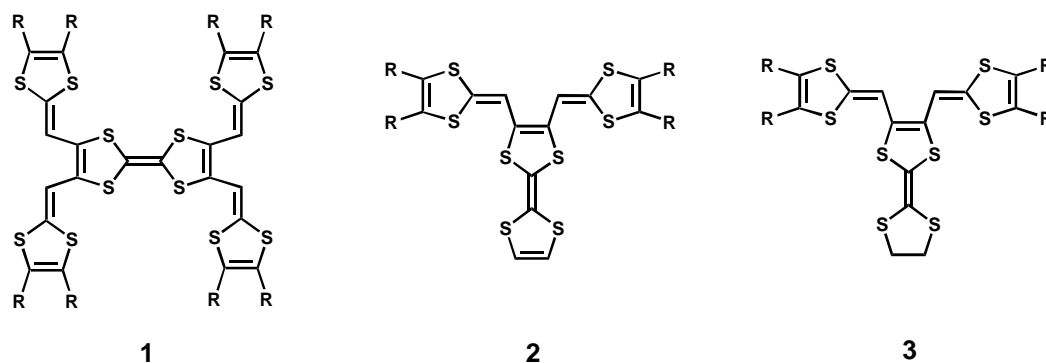
^aSolvent for ¹HNMR. ^bSolvent for recrystallization. ^cSolvent for chromatography.

- (1) Y. Misaki, T. Matsui, K. Kawakami, H. Nishikawa, T. Yamabe, and M. Shiro, *Chem. Lett.*, 1337 (1993).
- (2) Y. Misaki, K. Kawakami, T. Matsui, T. Yamabe, and M. Shiro, *J. Chem. Soc., Chem. Commun.*, 459 (1994).
- (3) R. R. Schumaker, and E. M. Engler, *J. Am. Chem. Soc.*, **99**, 5521 (1977).
- (4) R. R. Schumaker, and E. M. Engler, *J. Am. Chem. Soc.*, **102**, 6652 (1980).
- (5) E. M. Engler, and V. V. Patel, *J. Chem. Soc., Chem. Commun.*, 516 (1979).
- (6) H. Nishikawa, Diss. Kyoto University 1993.
- (7) H. Nishikawa, S. Kawauchi, Y. Misaki, and T. Yamabe, *Chem. Lett.*, 43 (1996).
- (8) Y. Misaki, K. Kawakami, H. Fujiwara, T. Miura, T. Kochi, M. Taniguchi, and T. Yamabe, *Mol. Cryst. Liq. Cryst.*, **296**, 77 (1997).
- (9) Y. Misaki, T. Miura, M. Taniguchi, H. Fujiwara, T. Yamabe, T. Mori, H. Mori, and S. Tanaka, *Adv. Mater.*, **9**, 714 (1997).
- (10) Y. Misaki, T. Miura, H. Fujiwara, K. Kawakami, T. Yamabe, T. Mori, H. Mori, and S. Tanaka, *Synth. Met.*, **86**, 1821 (1997).
- (11) Y. Misaki, T. Miura, K. Kawakami, H. Fujiwara, T. Yamabe, T. Mori, H. Mori, S. Tanaka, and M. Shiro, *Synth. Met.*, **70**, 1149 (1995).
- (12) Y. Misaki, H. Nishikawa, K. Kawakami, T. Yamabe, T. Mori, H. Inokuchi, H. Mori, and S. Tanaka, *Chem. Lett.*, 2073 (1993).
- (13) T. Mori, M. Ashizawa, M. Aragaki, K. Murata, Y. Misaki, and K. Tanaka, *Chem. Lett.*, 253 (1998).
- (14) Y. Misaki, T. Kochi, T. Yamabe, and T. Mori, *Adv. Mater.*, **10**, 588 (1998).
- (15) M. Fujiwara, M. Taniguchi, T. Maitani, Y. Misaki, K. Tanaka, K. Sako, K. Takakuwa, N. Morishita, and H. Tatemitsu, *Abstracts of 76th Annual Meeting of the Chemical Society of Japan II*, 3PA151 (1999).
- (16) J. Yamada, S. Satoki, S. Mishima, N. Akashi, K. Takahashi, N. Masuda, Y. Nishimoto, S. Tkasaki, and H. Anzai, *J. Org. Chem.*, **61**, 3987 (1996).
- (17) R. R. Schumaker, E. M. Engler, *J. Am. Chem. Soc.*, **102**, 6652 (1980).



X	mp/°C	solubility	E_1	E_2	CV (vs. SCE)	reference
O						1
S						1

(1) S. Yunoki, K. Takimiya, Y. Aso, and T. Otsubo, *Tetrahedron Lett.*, **38**, 3017 (1997).



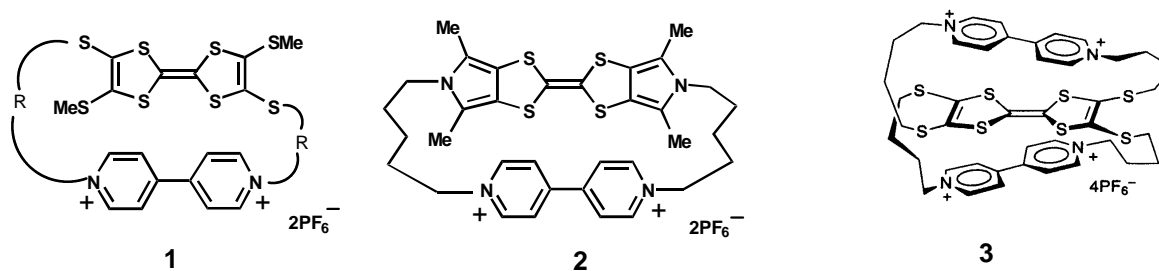
	R	mp/°C	solubility ^{a)}	E_1	E_2	E_3	CV (vs. SCE)	reference
1	H		DMF	0.19	0.34	0.50 ^{b)}	DMF 0.1M TBAP	1, 2, 3
	CO ₂ Me		DMF, TCE	0.32	0.65	0.81 ^{b)}	DMF 0.1M TBAP	1, 2, 3
				0.34	0.65	0.95	TCE 0.1M TBAP	1, 2, 3
	-(CH ₂) ₄ -		DMF, TCE	0.13	0.29	0.48	DMF 0.1M TBAP	1, 2, 3
				0.08	0.17	0.51	TCE 0.1M TBAP	1, 2, 3
	-(CH=CH) ₂ -						1, 2, 3	
2	H		DMF	0.22	0.30		DMF 0.1M TBAP	1, 2, 3
3	H		DMF, TCE	0.29			DMF 0.1M TBAP	1, 2, 3
				0.26	0.39	TCE 0.1M TBAP	1, 2, 3	
	CO ₂ Me		DMF, TCE	0.51	0.58		DMF 0.1M TBAP	1, 2, 3
				0.51	0.74	TCE 0.1M TBAP	1, 2, 3	

^{a)}Solvent for CV. ^{b)}Irreversible.

(1) M. Sallé, M. Jubault, A. Gorgues, K. Boubekeur, M. Fourmigué, P. Batail, and E. Vanadell, *Chem. Mater.*, **5**, 1196 (1991).

(2) M. Sallé, P. Frere, A. Gorgues, and M. Jubault, *Phosphorus, Sulfur, and Silicon*, **74**, 473 (1991).

(3) M. Sallé, A. Gorgues, M. Jubault, and Y. Gouriou, *Synth. Met.*, **41-43**, 2575 (1991).

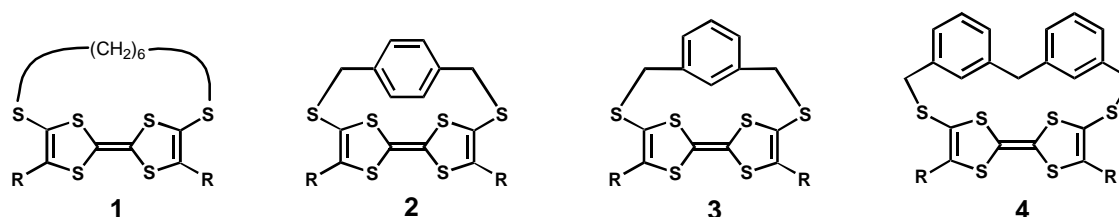


	R		mp/°C	solubility ^{a)}	E_1	E_2	E_3	E_4	CV (vs. SCE)	reference
1	-(CH ₂) ₄ -	<i>trans</i>	217 (dec.)	DMSO	-0.9	-0.4	0.58	0.82	CH ₃ CN 0.1M TBAHP	1
	-(CH ₂) ₅ -	<i>cis/trans</i>	144-145 (dec.)	DMSO	-0.9	-0.4	0.54	0.78	CH ₃ CN 0.1M TBAHP	1
	-(CH ₂) ₂ O(CH ₂) ₂ -	<i>cis/trans</i>	215-217 (dec.)	DMSO	-0.9	-0.40	0.51	0.76	CH ₃ CN 0.1M TBAHP	1
2			>250	DMSO	-0.8	-0.4	0.45	0.76	CH ₃ CN 0.1M TBAHP	1
3		<i>trans</i>	175 (dec.)	DMSO	0.64	0.94			CH ₃ CN 0.1M TBAHP ^{b)}	2

^aSolvent for ¹HNMR. ^bV vs. Ag / AgCl.

(1) K. B. Simonsen, K. Zong, R. D. Rogers, and M. P. Cava, *J. Org. Chem.*, **62**, 679 (1997).

(2) K. B. Simonsen, N. Thorup, M. P. Cava, and J. Becher, *Chem. Commun.*, 901 (1998).

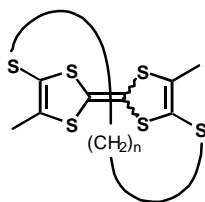


	R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. Ag / AgCl)	reference
1	<i>p</i> -MeC ₆ H ₄		CHCl ₃	0.46 ^{b)}		CH ₂ Cl ₂ 0.1M TEAT	1
2	<i>p</i> -MeC ₆ H ₄		CHCl ₃	0.46 ^{b)}		CH ₂ Cl ₂ 0.1M TEAT	1
	CO ₂ Me	224	CHCl ₃	1.00 ^{b)}		CH ₃ CN TBAHP	2
	H	>184 (dec.)	CHCl ₃	0.81 ^{b)}		CH ₂ Cl ₂ TBAHP	2
3	CO ₂ Me	233	CHCl ₃	1.05 ^{b)}		CH ₃ CN TBAHP	2
4	<i>cis</i>	192-194	CHCl ₃	0.39	0.83	CH ₃ CN TBAHP	2
4	<i>trans</i>	210-212	CHCl ₃	0.44	0.83	CH ₃ CN TBAHP	2

^aSolvent for ¹HNMR. ^bThe peak potential of an irreversible anodic wave

(1) F. Bertho-Thoraval, A. Robert, A. Souizi, K. Boubekeur, and P. Batail, *J. Chem. Soc., Chem. Commun.*, 843 (1992).

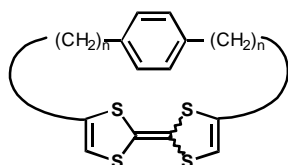
(2) J. Lau, P. Blanchard, A. Riou, M. Jubault, M. P. Cava, and J. Becher, *J. Org. Chem.*, **62**, 4936 (1997).



n		mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
10	<i>trans</i>	158-159	CHCl ₃	0.47		CH ₂ Cl ₂	0.1M TBAHP	1
	<i>cis</i>			0.4	0.75	CH ₂ Cl ₂	0.1M TBAHP	1
12	<i>trans</i>	115-116	CHCl ₃	0.48		CH ₂ Cl ₂	0.1M TBAHP	1
	<i>cis</i>			0.45	0.83	CH ₂ Cl ₂	0.1M TBAHP	1

^aSolvent for ¹HNMR. ^bV vs. Ag / AgCl.

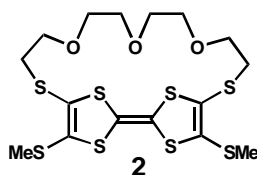
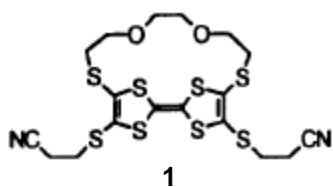
(1) K. Boubeker, C. Lenoir, P. Batail, R. Carlier, A. Tallec, M-P. Le Paillard, D. Lorcy, and A. Robert, *Angew. Chem. Int. Ed. Engl.*, **33**, 1379 (1994).



n		mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
3	<i>trans</i>	180-182	cyclohexane				1
	<i>cis</i>						1
4	<i>trans</i>						1
	<i>cis</i>	157-158					1

^aSolvent for recrystallization.

(1) H. A. Staab, J. Ippen, C. Tao-pen, C. Krieger, and B. Starker, *Angew. Chem., Int. Ed. Engl.*, **19**, 66 (1980).

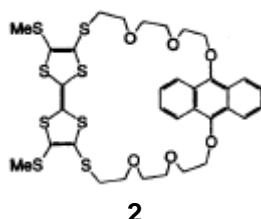
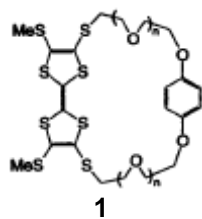


		mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
1	(<i>cis/trans</i>)		CH ₃ CN ^{b)}	0.50	0.77	CH ₃ CN	0.1M TBAHP	1
2	(<i>cis/trans</i>)	oil	CHCl ₃					2

^aSolvent for CV. ^bV vs. Ag / AgCl.

(1) F. L. Derf, M. Sallé, M. Mazari, J. Becher, M. Jubault, A. Gorgues, J. Orduna, and J. Garín, *Synth. Met.*, **94**, 49 (1998).

(2) Z. -T. Li, P. C. Stein, J. Becher, D. Jensen, P. Mørk, and N. Svenstrup, *Chem. Eur. J.*, **2**, 624 (1996).



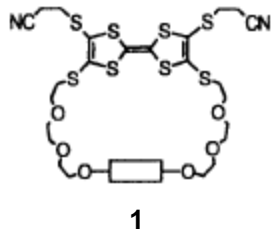
n	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. Ag / AgCl)	reference	
1 0 (cis/trans)						1	
1 (trans)	99-101	CHCl ₃	0.46	0.74	1.01	CH ₃ CN 0.1M TBAHP	2
2 (cis/trans)	oil	CHCl ₃	0.53	0.83		CH ₂ Cl ₂ 0.1M TBAHP	3
2 (cis/trans)	oil	CHCl ₃	0.43	0.77	1.41 ^{b)}	CH ₂ Cl ₂ 0.1M TBAHP	3

^aSolvent for ¹HNMR. ^bIrreversible.

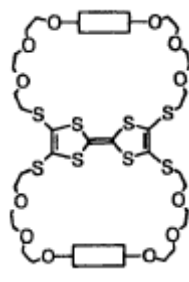
(1) M. B. Nielsen, and J. Becher, *Liebigh Ann.*, 2177 (1997).

(2) J. Becher, J. Lau, P. Leriche, P. Mørk, and N. Svenstrup, *J. Chem. Soc., Chem. Commun.*, 2715 (1994).

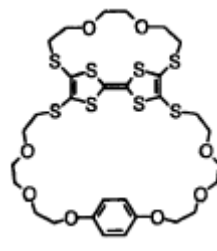
(3) Z. -T. Li, P. C. Stein, J. Becher, D. Jensen, P. Mørk, and N. Svenstrup, *Chem. Eur. J.*, **2**, 624 (1996).



(cis/trans)



(cis/trans)

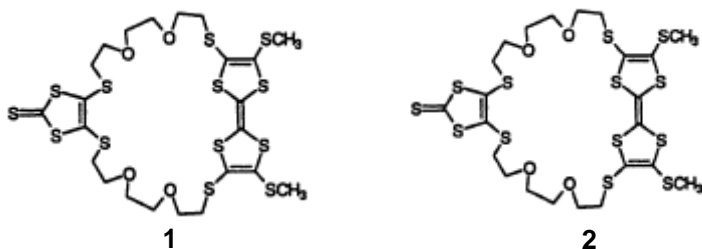


(cis/trans)

	——	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference	
1		oil	CHCl ₃			CH ₂ Cl ₂ 0.1M TBAHP	1	
		oil	CHCl ₃			CH ₂ Cl ₂ 0.1M TBAHP	1	
		oil	CHCl ₃			CH ₂ Cl ₂ 0.1M TBAHP	1	
		oily solid	CHCl ₃			CH ₂ Cl ₂ 0.1M TBAHP	1	
2		oil	CHCl ₃	0.50	0.79	1.38 ^{b)}	CH ₂ Cl ₂ 0.1M TBAHP	1
		oil	CHCl ₃	0.38	0.73	1.05 ^{b)}	CH ₂ Cl ₂ 0.1M TBAHP	1
		oil	CHCl ₃	0.37	0.68	1.01	CH ₂ Cl ₂ 0.1M TBAHP	1
		oily solid	CHCl ₃	0.40	0.70	1.06	CH ₂ Cl ₂ 0.1M TBAHP	1
3		oil	CHCl ₃				1	

^aSolvent for ¹HNMR. ^bIrreversible.

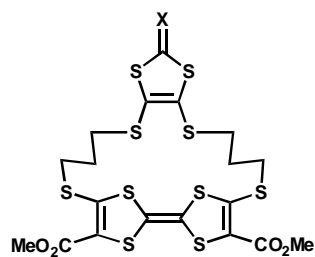
(1) Z. -T. Li, P. C. Stein, J. Becher, D. Jensen, P. Mørk, and N. Svenstrup, *Chem. Eur. J.*, **2**, 624 (1996).



	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1 (cis/trans)	oil	CHCl ₃				1
2 (cis/trans)	oil	CHCl ₃				1

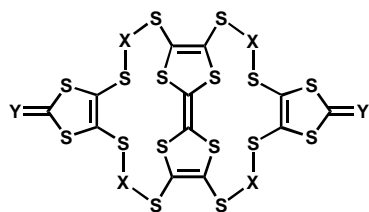
^aSolvent for ¹HNMR.

(1) M. B. Nielsen, Z. -T. Li, and J. Becher, *J. Mater. Chem*, **7**, 1175 (1997).



X	mp/°C	solubility	E_1	E_2	CV (vs. SCE)	reference
S (cis/trans)						1
O (cis/trans)						1

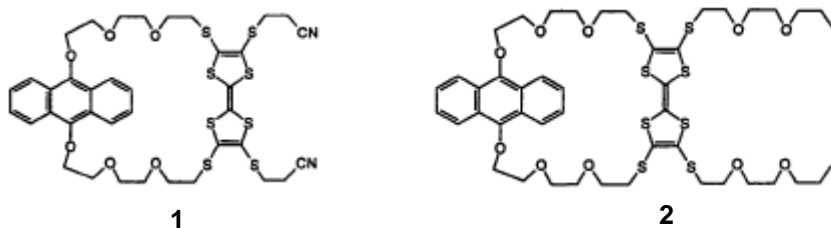
(1) S. Yunoki, K. Takimiya, Y. Aso, and T. Otsubo, *Tetrahedron Lett.*, **38**, 3017 (1997).



	X	Y	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1	-(CH ₂) ₂ -	S	270 (dec.)	CS ₂ -CHCl ₃				1
	-(CH ₂) ₃ -	S	231-232 (dec.)	CS ₂ -CHCl ₃				1, 2
	-(CH ₂) ₄ -	S	199 (dec.)	CS ₂ -CHCl ₃				1
	-(CH ₂) ₅ -	S	201 (dec.)	CS ₂ -CHCl ₃				1
	-(CH ₂) ₂ -	O	254 (dec.)	CS ₂ -CHCl ₃				1
	-(CH ₂) ₃ -	O	234 (dec.)	CS ₂ -CHCl ₃				1, 2

	-(CH ₂) ₄ -	O	207-208 (dec.)	CS ₂ -CHCl ₃	1
	-(CH ₂) ₅ -	O	130-131	CS ₂ -CHCl ₃	1
2	-(CH ₂ CH ₂ O) ₂ CH ₂ CH ₂ -	O			3

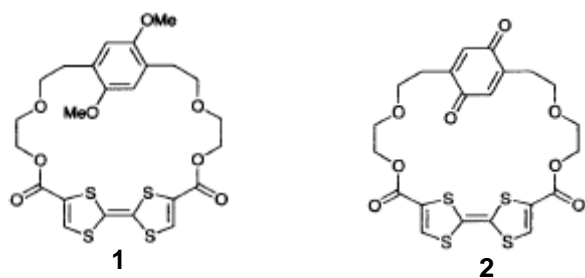
- (1) K. Takimiya, K. Imamura, Y. Shibata, Y. Aso, F. Ogura, and T. Otsubo, *J. Org. Chem.*, **62**, 5567 (1997).
 (2) K. Takimiya, Y. Shibata, K. Imamura, A. Kashiara, Y. Aso, T. Otsubo, and F. Ogura, *Tetrahedron Lett.*, **36**, 5045 (1995).
 (3) M. B. Nielsen, and J. Becher, *Liebigs Ann.*, 2177 (1997).



	mp/°C	solubility ^{a)}	<i>E</i> ₁	<i>E</i> ₂	CV (vs. SCE)	reference
1	(<i>cis/trans</i>)					1
2	(<i>cis/trans</i>) semicrystalline	CHCl ₃				2

^aSolvent for ¹HNMR.

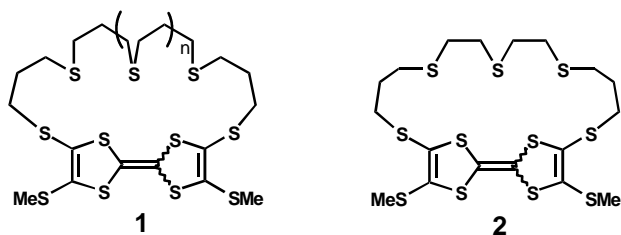
- (1) Z. -T. Li, P. C. Stein, N. Svenstrup, K. H. Lund, and J. Becher, *Angew. Chem. Int. Ed. Engl.*, **34**, 2524 (1995).
 (2) M. B. Nielsen, Z. -T. Li, and J. Becher, *J. Mater. Chem.*, **7**, 1175 (1997).



	mp/°C	solubility ^{a)}	<i>E</i> ₁	<i>E</i> ₂	CV (vs. SCE)	reference
1						1
2		CHCl ₃				1

^aSolvent for UV.

- (1) R. M. Moriarty, A. Tao, R. Gilardi, Z. Song, and S. M. Tuladhar, *Chem. Commun.*, 157 (1998).

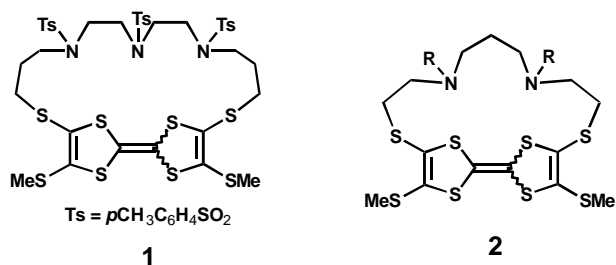


	n	mp/°C	solubility	E_1	E_2	CV (vs. SCE)	reference	
1	0		CH ₃ CN ^{a)}	0.50	0.77	CH ₃ CN	0.1M TBAHP	1
				0.59	0.89	CH ₂ Cl ₂ -CH ₃ CN	0.1M TBAHP ^{b)}	2
	1		CH ₃ CN ^{a)}	0.50	0.77	CH ₃ CN	0.1M TBAHP	1
				0.59	0.89	CH ₂ Cl ₂ -CH ₃ CN	0.1M TBAHP ^{b)}	2
2				0.59	0.89	CH ₂ Cl ₂ -CH ₃ CN	0.1M TBAHP ^{b)}	2

^aSolvent for CV. ^bV vs. Ag / AgCl.

(1) J. Becher, J. Lau, P. Leriche, P. Mørk, and N. Svenstrup, *J. Chem. Soc., Chem. Commun.*, 2715 (1994).

(2) F. Le Derf, M. Mazari, N. Mercier, E. Levillain, P. Richomme, J. Becher, J. Garín, J. Orduna, A. Gorghues, and M. Sallé, *Chem. Commun.*, 1417 (1999).



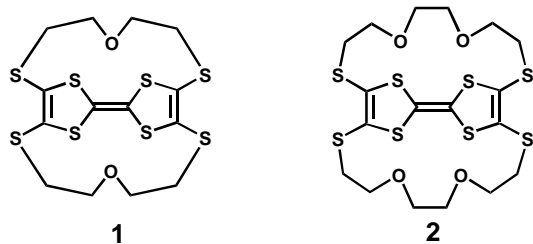
	R	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference	
1			CHCl ₃	0.57	0.93	CH ₂ Cl ₂	0.1M TBAHP	1
2	CH ₃		CHCl ₃	0.50	0.77	CH ₃ CN	0.1M TBAHP	2
	CH ₃		CHCl ₃	0.58	0.84	CH ₂ Cl ₂	0.1M TBAHP	1
	CF ₃ SO ₂		CHCl ₃	0.50	0.77	CH ₃ CN	0.1M TBAHP	2
	CF ₃ SO ₂		CHCl ₃	0.56	0.79	CH ₂ Cl ₂	0.1M TBAHP	1
	CH ₃ C ₆ H ₄ SO ₂		CHCl ₃ ^{b)}	0.56	0.79	CH ₂ Cl ₂	0.1M TBAHP	3

^aSolvent for ¹HNMR. ^bSolvent for CV

(1) F. Le Derf, M. Sallé, N. Mercier, J. Becher, P. Rivhomme, A. Gorghues, J. Orduna, and J. Garín, *Eur. J. Org. Chem.*, 1861 (1998).

(2) J. Becher, J. Lau, P. Leriche, P. Mørk, and N. Svenstrup, *J. Chem. Soc., Chem. Commun.*, 2715 (1994).

(3) F. Le Derf, M. Sallé, M. Mazari, N. Mercier, A. Riou, A. Belyasmine, J. Orduna, J. Garin, J. Becher, and A. Gorghues, *Synth. Met.*, **102**, 1461 (1999).

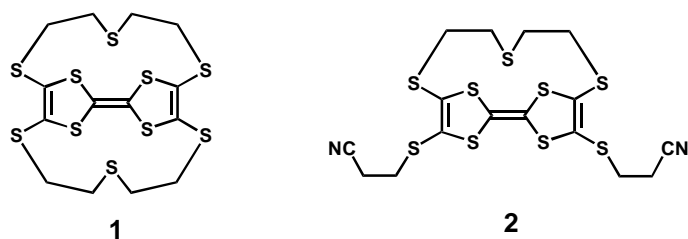


	mp/°C	solubility	E_1	E_2	CV (vs. SCE)		reference
1	>270	CHCl ₃	1.26 ^{a)}		CH ₃ CN	0.1M TBAHP	1
2	247	CHCl ₃	0.41	0.73	TCE	0.1M TBAP	1, 2

^aThe peak potential of an irreversible anodic wave.

(1) T. K. Hansen, T. Jørgensen, F. Jensen, P. H. Thygesen, K. Christiansen, M. B. Hursthouse, M. E. Harman, M. A. Malik, B. Girmay, A. E. Underhill, M. Begtrup, J. D. Kilburn, K. Belmore, P. Roepstorff, and J. Becher, *J. Org. Chem.*, **58**, 1359 (1993).

(2) J. Becher, T. K. Hansen, N. Malotra, G. Bojesen, S. Bwadt, K. S. Varma, B. Girmay, J. D. Kilburn, and A. E. Underhill, *J. Chem. Soc., Perkin Trans. 1*, 175 (1990).

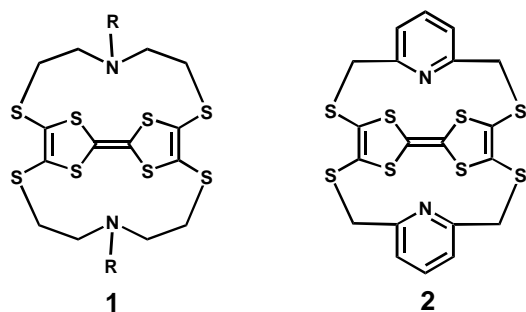


	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)		reference
1	130-132 (dec.)						1
2	172-176	CHCl ₃					2

^aSolvent for ¹HNMR.

(1) T. Jørgensen, B. Girmay, T. K. Hansen, J. Becher, A. E. Underhill, M. B. Hursthouse, M. E. Harman, and J. D. Kilburn, *J. Chem. Soc., Perkin Trans. 1*, 2907 (1992).

(2) S. Zeltner, R. M. Olk, M. Wagner, B. Olk, *Synthesis*, 1445 (1994).

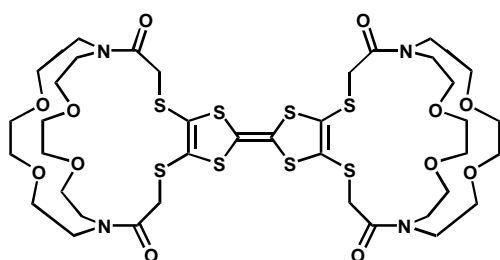
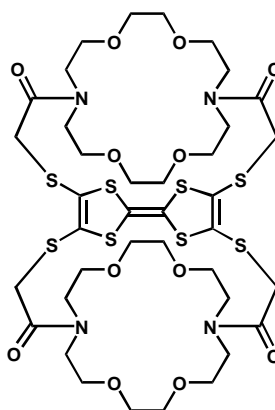


	R	mp/°C	solubility	E_1	E_2	CV (vs. SCE)		reference
1	CH ₃	248-249	CHCl ₃ ^{a)}	0.95 ^{c)}		CH ₂ Cl ₂	0.1M TBAHP	1, 3
	C ₂ H ₅	203-204	CHCl ₃ ^{a)}					1, 3

2 290-292 CHCl_3^{b} 0.27 0.57 CH_2Cl_2 0.1M TBAP^d) 2, 3

^aSolvent for recrystallization. ^bSolvent for UV. ^cThe peak potential of an irreversible anodic wave. ^dV vs. Ag / AgCl.

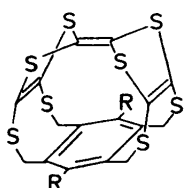
- (1) T. Jørgensen, J. Becher, T. K. Hansen, K. Christiansen, P. Roepstorff, S. Larsen, and A. Nygaard, *Adv. Mater.*, **3**, 486 (1991).
 (2) B. Girmay, J. D. Kilburn, A. E. Underhill, K. S. Varma, M. B. Hurthouse, M. E. Harman, J. Becher, G. Bojesen, *J. Chem. Soc., Chem. Commun.*, 1406 (1989).
 (3) T. K. Hansen, T. Jørgensen, F. Jensen, P. H. Thygesen, K. Christiansen, M. B. Hursthouse, M. E. Harman, M. A. Malik, B. Girmay, A. E. Underhill, M. Begtrup, J. D. Kilburn, K. Belmore, P. Roepstorff, and J. Becher, *J. Org. Chem.*, **58**, 1359 (1993).

**1****2**

	mp/°C	solubility ^a	E_1^{b}	E_2^{b}	E_1^{c}	E_2^{c}	CV (vs. SCE)	reference
1	230-232 (dec.)	CHCl_3	0.50	0.81	0.43	0.72	CH_2Cl_2 - CH_3CN 0.1M TBAHP	1
2	210 (dec.)		0.52	0.76	0.44	0.67	CH_2Cl_2 - CH_3CN 0.1M TBAHP	1

^aSolvent for ¹HNMR. ^bAnodic peak potential. ^cCathodic peak potential.

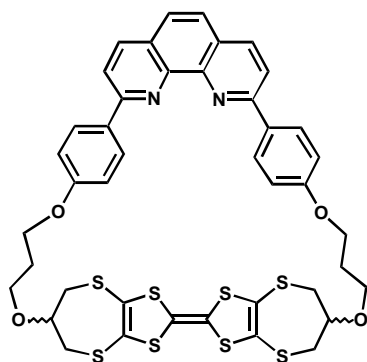
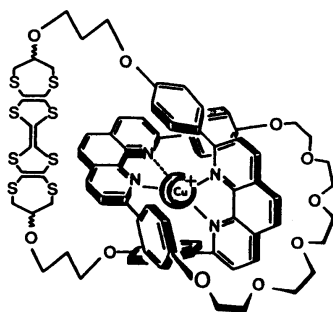
- (1) R. Gasiorowski, T. Jørgensen, J. Møller, T. K. Hansen, M. Pietraszkiewicz, and J. Becher, *Adv. Mater.*, **4**, 568 (1992).



R	mp/°C	solubility ^a	E_1	E_2	CV (vs. SCE)	reference
H			1.09 ^b		CH_2Cl_2 0.1M TBAHP	1
OC_3H_7	227 (dec.)	CHCl_3	0.93 ^b			2, 3
OC_4H_9	236 (dec.)	CHCl_3				3
OC_6H_{13}	205 (dec.)	CHCl_3				2, 3
$\text{OC(O)C}_5\text{H}_{11}$	186 (dec.)	CHCl_3				3

^aSolvent for ¹HNMR. ^bIrreversible.

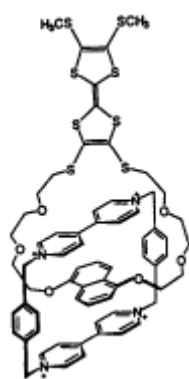
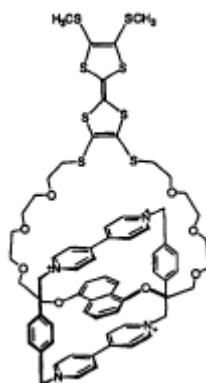
- (1) T. K. Hansen, T. Jrgensen, F. Jensen, P. H. Thygesen, K. Christiansen, M. B. Hursthouse, M. E. Harman, M. A. Malik, B. Girmay, A. E. Underhill, M. Begtrup, J. D. Kilburn, K. Belmore, P. Roepstorff, and J. Becher, *J. Org. Chem.*, **58**, 1359 (1993).
 (2) J. Röhrich, P. Wolf, V. Enkelmann, and K. Müllen, *Angew. Chem. Int. Ed. Engl.*, **27**, 1377 (1988).
 (3) J. Röhrich, and K. Müllen, *J. Org. Chem.*, **57**, 2374 (1992).

**1****2**

	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1		CH ₂ Cl ₂				1
2		CH ₂ Cl ₂				1

^aSolvent for ¹HNMR.

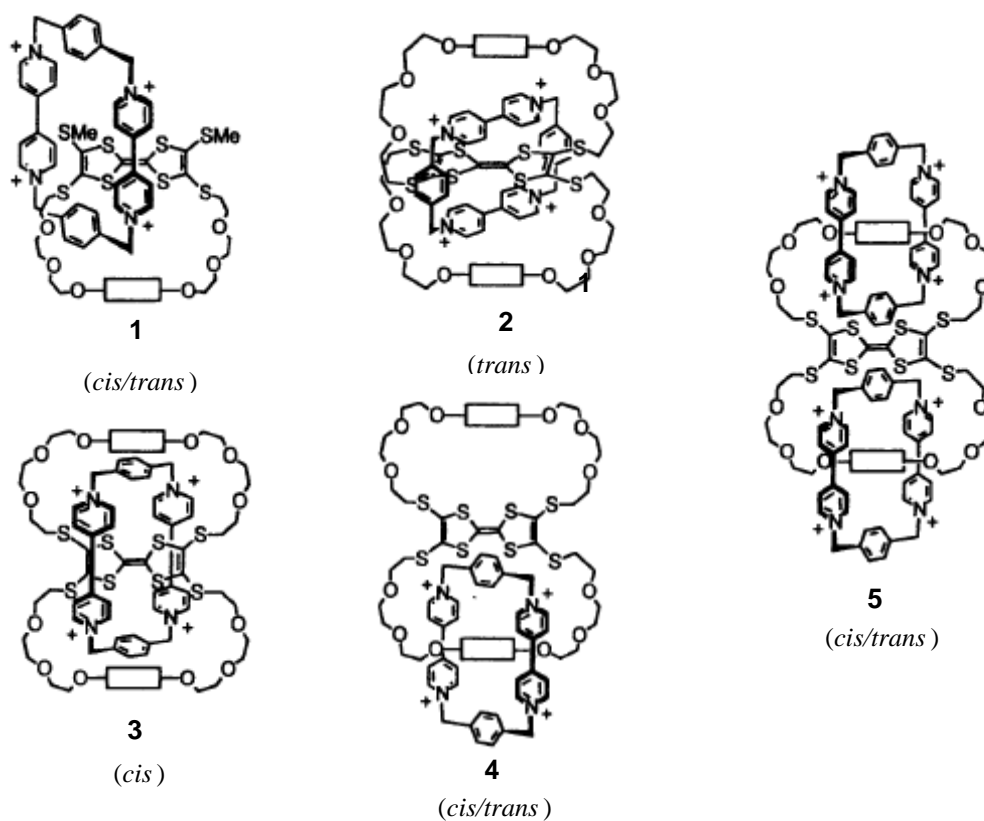
- (1) T. Jørgensen, J. Becher, J. C. Chambron, and J. P. Sauvage, *Tetrahedron Lett.*, **35**, 4339 (1994).

**1****2**

	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. Ag / AgCl)	reference
1 · 4PF ₆	213-215 (dec.)	CH ₃ CN	0.56	0.79	CH ₂ Cl ₂ -MeCN (10% v/v)	0.1M TBAHF 1
2 · 4PF ₆	>250	CH ₃ CN	0.57	0.81	CH ₂ Cl ₂ -MeCN (10% v/v)	0.1M TBAHF 1

^aSolvent for ¹HNMR.

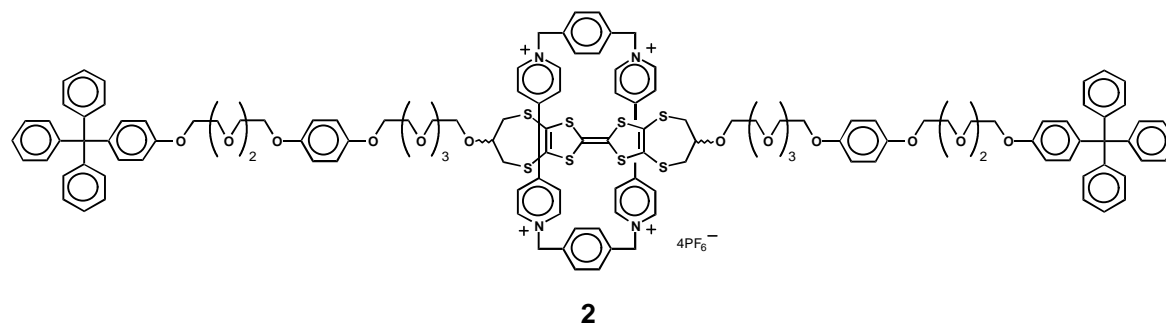
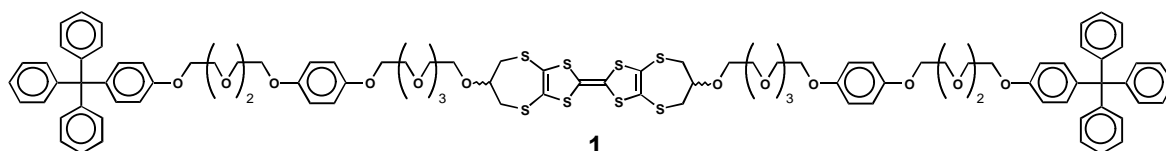
- (1) T. Jørgensen, J. Becher, J. C. Chambron, and J. P. Sauvage, *Tetrahedron Lett.*, **35**, 4339 (1994).



		mp/°C	solubility ^{a)}	E_1	E_2	E_3	CV (vs. Ag / AgCl)	reference
1	• 4PF ₆	146 (dec.)	CH ₃ CN	0.60	0.84		CH ₃ CN 0.1M TBAHP	1
		178 (dec.)	CH ₃ CN	0.60 ^{o)}			CH ₃ CN 0.1M TBAHP	1
2	• 4PF ₆	220 (dec.)	CH ₃ CN	0.63	0.94	1.34	CH ₃ CN 0.1M TBAHP	1
		250 (dec.)	CH ₃ CN	0.52 ^{o)}	0.87 ^{o)}	1.19	CH ₃ CN 0.1M TBAHP	1
		230 (dec.)	CH ₃ CN				CH ₃ CN 0.1M TBAHP	1
		205 (dec.)	CH ₃ CN	0.46		1.01	CH ₃ CN 0.1M TBAHP	1
3	• 4PF ₆	185 (dec.)	CH ₃ CN	0.62 ^{o)}	0.92 ^{o)}	1.34	CH ₃ CN 0.1M TBAHP	1
		195 (dec.)	CH ₃ CN				CH ₃ CN 0.1M TBAHP	1
4	• 4PF ₆	200 (dec.)	CH ₃ CN ^{b)}	0.58	0.82	1.28	CH ₃ CN 0.1M TBAHP	1
		198 (dec.)	CH ₃ CN ^{b)}	0.60	0.85	1.03	CH ₃ CN 0.1M TBAHP	1
5	• 8PF ₆	215 (dec.)	CH ₃ CN ^{b)}	0.59		1.00	CH ₃ CN 0.1M TBAHP	1

^{a)}Solvent for ¹HNMR. ^{b)}Solvent for CV. ^{o)}The peak potential of an irreversible anodic wave.

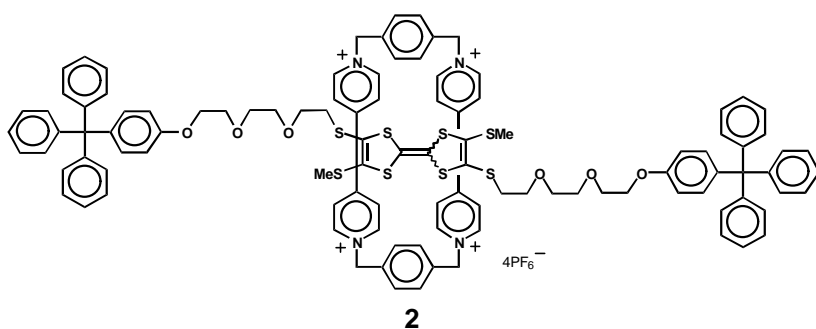
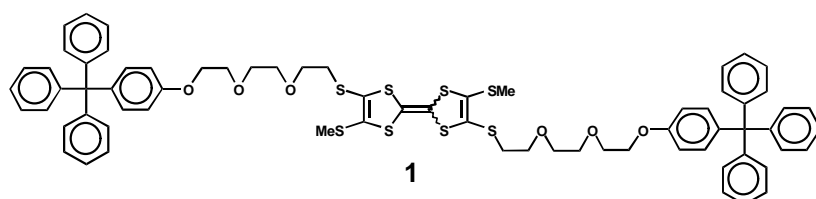
(1) Z. -T. Li, P. C. Stein, J. Becher, D. Jensen, P. Mørk, and N. Svenstrup, *Chem. Eur. J.*, **2**, 624 (1996).



	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1		CHCl ₃				1
2		acetone				1

^aSolvent for ¹HNMR.

(1) P. R. Ashton R. A. Bissell, N. Spencer, J. F. Stoddart, and M. S. Tolley, *Synlett.*, 923 (1992).



	mp/°C	solubility ^{a)}	E_1	E_2	CV (vs. SCE)	reference
1^{b)}	144-146	CHCl ₃	0.54	0.87	CH ₂ Cl ₂ .1M TBAHI	1
	83-85	CHCl ₃				
2	153 (dec.)	CH ₃ CN	0.61	0.94	CH ₃ CN .1M TBAHI	1

^aSolvent for ¹HNMR. ^bTwo isomers not assigned as *cis* or *trans* isomer.

(1) Z. -T. Li, P. C. Stein, J. Bicher, D. Jensen, P. Mørk, and N. Svenstrup, *Chem. Eur. J.*, **2**, 624 (1996).